

=> FIL REG

FILE 'REGISTRY' ENTERED AT 16:02:48 ON 18 JUN 2010
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=> D HIS NOFILE

FILE 'HCAPLUS' ENTERED AT 13:22:46 ON 18 JUN 2010

E US2006-567430/APPS

L1 1 SEA SPE=ON ABB=ON PLU=ON US2006-567430/AP

E WO2004-CA1461/APPS

L2 1 SEA SPE=ON ABB=ON PLU=ON (WO2004-CA1461/AP OR WO2004-CA1461/PRN)

L3 1 SEA SPE=ON ABB=ON PLU=ON (L1 OR L2)
SEL L3 RN

FILE 'REGISTRY' ENTERED AT 13:23:26 ON 18 JUN 2010

L4 5 SEA SPE=ON ABB=ON PLU=ON (183892-60-6/BI OR 333305-83-2/

FILE 'HCAPLUS' ENTERED AT 13:24:56 ON 18 JUN 2010

SEL L3 AU

L5 13 SEA SPE=ON ABB=ON PLU=ON "COTE, SIMON"/AU

E MATRIX INNOVATION/CO

L6 2 SEA SPE=ON ABB=ON PLU=ON "MATRIX INNOVATION INC"+ALL/CO,
CS,PA

FILE 'LREGISTRY' ENTERED AT 14:32:18 ON 18 JUN 2010

L7 STR

FILE 'REGISTRY' ENTERED AT 14:37:46 ON 18 JUN 2010

L8 0 SEA SSS SAM L7

FILE 'LREGISTRY' ENTERED AT 14:38:20 ON 18 JUN 2010

L9 STR L7

FILE 'REGISTRY' ENTERED AT 14:41:08 ON 18 JUN 2010

L10 0 SEA SSS SAM L9

FILE 'LREGISTRY' ENTERED AT 14:42:06 ON 18 JUN 2010

L11 STR L9

FILE 'REGISTRY' ENTERED AT 14:43:26 ON 18 JUN 2010

L12 1 SEA SSS SAM L11

L13 207337 SEA SPE=ON ABB=ON PLU=ON C2H4O OR C3H6O OR C4H8O

L14 7 SEA SUB=L13 SSS SAM L11

FILE 'LREGISTRY' ENTERED AT 14:50:15 ON 18 JUN 2010

L15 STR L7

FILE 'REGISTRY' ENTERED AT 14:51:29 ON 18 JUN 2010

L16 0 SEA SSS SAM L15

L17 0 SEA SUB=L13 SSS SAM L15

FILE 'LREGISTRY' ENTERED AT 14:53:11 ON 18 JUN 2010

L18 STR

L19 STR L18

FILE 'REGISTRY' ENTERED AT 15:00:34 ON 18 JUN 2010

L20 0 SEA SSS SAM L19

FILE 'LREGISTRY' ENTERED AT 15:01:34 ON 18 JUN 2010
L21 STR L19

FILE 'REGISTRY' ENTERED AT 15:12:09 ON 18 JUN 2010
L22 4 SEA SSS SAM L21
L23 50 SEA SUB=L13 SSS SAM L21
L24 STR L21
L25 24 SEA SUB=L13 SSS SAM L24

FILE 'LREGISTRY' ENTERED AT 15:23:13 ON 18 JUN 2010
L26 STR L24

FILE 'REGISTRY' ENTERED AT 15:25:25 ON 18 JUN 2010
L27 0 SEA SUB=L13 SSS SAM L26
L28 621 SEA SUB=L13 SSS FUL L24
SAV L28 KAH430/A
L29 0 SEA SUB=L28 SSS SAM L26
L30 0 SEA SUB=L28 SSS FUL L26
L31 4 SEA SPE=ON ABB=ON PLU=ON L28 AND L4

FILE 'HCAPLUS' ENTERED AT 15:32:22 ON 18 JUN 2010
L32 344 SEA SPE=ON ABB=ON PLU=ON L28
L33 598582 SEA SPE=ON ABB=ON PLU=ON CROSSLINK? OR CROSS (2A) LINK?
OR CURE OR CURED OR CURING? OR CURABL?
L34 36 SEA SPE=ON ABB=ON PLU=ON L32 AND L33
L35 751862 SEA SPE=ON ABB=ON PLU=ON POLYOXYALKYLENE? OR POLYETHER?
OR ?GLYCOL?
L36 59765 SEA SPE=ON ABB=ON PLU=ON L35 (L) L33
L37 25 SEA SPE=ON ABB=ON PLU=ON L34 AND L36
L38 TRA PLU=ON L37 1- RN HIT : 40 TERMS

FILE 'REGISTRY' ENTERED AT 15:44:03 ON 18 JUN 2010
L39 40 SEA SPE=ON ABB=ON PLU=ON L38

FILE 'LREGISTRY' ENTERED AT 15:50:25 ON 18 JUN 2010
L40 STR L26

FILE 'REGISTRY' ENTERED AT 15:52:00 ON 18 JUN 2010
L41 8 SEA SUB=L28 SSS SAM L40
L42 104 SEA SUB=L28 SSS FUL L40

FILE 'HCAPLUS' ENTERED AT 15:54:14 ON 18 JUN 2010
L43 27 SEA SPE=ON ABB=ON PLU=ON L42
L44 6 SEA SPE=ON ABB=ON PLU=ON L43 AND L33
L45 18 SEA SPE=ON ABB=ON PLU=ON L43 AND L35
L46 4 SEA SPE=ON ABB=ON PLU=ON L45 AND L33
L47 18 SEA SPE=ON ABB=ON PLU=ON L46 OR L45
L48 1 SEA SPE=ON ABB=ON PLU=ON L47 AND (L5 OR L6)
L49 17 SEA SPE=ON ABB=ON PLU=ON L47 NOT L48
L50 15 SEA SPE=ON ABB=ON PLU=ON 1808-2006/PY,PRY,AY AND L49

FILE 'REGISTRY' ENTERED AT 16:02:48 ON 18 JUN 2010

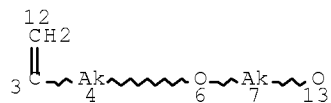
=> D L30 QUE STAT

June 18, 2010

10/567,430

3

L13 207337 SEA FILE=REGISTRY SPE=ON ABB=ON PLU=ON C2H4O OR C3H6O
OR C4H8O
L24 STR



NODE ATTRIBUTES:

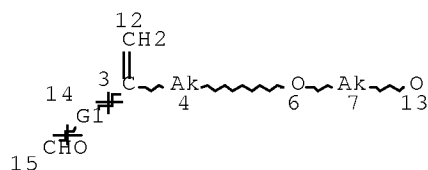
CONNECT IS E3 RC AT 3
CONNECT IS E2 RC AT 4
CONNECT IS E2 RC AT 7
DEFAULT MLEVEL IS ATOM
GGCAT IS SAT AT 4
GGCAT IS SAT AT 7
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 6

STEREO ATTRIBUTES: NONE

L26 STR



A @16

REP G1=(0-20) 16

NODE ATTRIBUTES:

NSPEC IS RC AT 16
CONNECT IS E3 RC AT 3
CONNECT IS E2 RC AT 4
CONNECT IS E2 RC AT 7
DEFAULT MLEVEL IS ATOM
GGCAT IS SAT AT 4
GGCAT IS SAT AT 7
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 9

STEREO ATTRIBUTES: NONE

L28 621 SEA FILE=REGISTRY SUB=L13 SSS FUL L24
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100.0% PROCESSED 469 ITERATIONS
SEARCH TIME: 00.00.01

0 ANSWERS

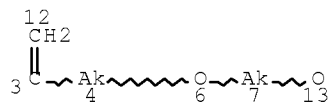
=> D L42 QUE STAT

June 18, 2010

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4

L13 207337 SEA FILE=REGISTRY SPE=ON ABB=ON PLU=ON C2H4O OR C3H6O
 OR C4H8O
L24 STR



NODE ATTRIBUTES:

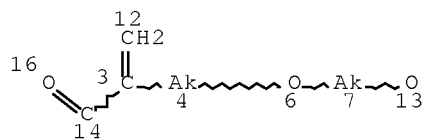
CONNECT IS E3 RC AT 3
CONNECT IS E2 RC AT 4
CONNECT IS E2 RC AT 7
DEFAULT MLEVEL IS ATOM
GGCAT IS SAT AT 4
GGCAT IS SAT AT 7
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 6

STEREO ATTRIBUTES: NONE

L28 621 SEA FILE=REGISTRY SUB=L13 SSS FUL L24
L40 STR



NODE ATTRIBUTES:

CONNECT IS E3 RC AT 3
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CONNECT IS E2 RC AT 7
DEFAULT MLEVEL IS ATOM
GGCAT IS SAT AT 4
GGCAT IS SAT AT 7
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 8

STEREO ATTRIBUTES: NONE

L42 104 SEA FILE=REGISTRY SUB=L28 SSS FUL L40

100.0% PROCESSED 291 ITERATIONS
SEARCH TIME: 00.00.01

104 ANSWERS

=> FIL HCAP

FILE 'HCAPLUS' ENTERED AT 16:03:19 ON 18 JUN 2010

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=> D L48 1 IBIB ABS HITSTR HITIND RETABLE

L48 ANSWER 1 OF 1 HCAPLUS COPYRIGHT 2010 ACS on STN
ACCESSION NUMBER: 2005:120909 HCAPLUS Full-text
DOCUMENT NUMBER: 142:198979
TITLE: New polyether based monomers,
crosslinkers, and highly
crosslinked amphiphile polyether
resins
INVENTOR(S): Cote, Simon
PATENT ASSIGNEE(S): Matrix Innovation Inc., Can.
SOURCE: PCT Int. Appl., 75 pp.
CODEN: PIXXD2
DOCUMENT TYPE: Patent
LANGUAGE: English
FAMILY ACC. NUM. COUNT: 1
PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 2005012277	A1	20050210	WO 2004-CA1461	20040804
W:	AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW			
RW:	BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG			
CA 2534616	A1	20050210	CA 2004-2534616	20040804
EP 1687343	A1	20060809	EP 2004-761625	20040804
R:	AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, FI, RO, CY, TR, BG, CZ, EE, HU, PL, SK			
CN 1856483	A	20061101	CN 2004-80027888	20040804
JP 2007501296	T	20070125	JP 2006-522190	20040804
US 20060241245	A1	20061026	US 2006-567430	20060425
PRIORITY APPLN. INFO.:			US 2003-491969P	P 20030804
			WO 2004-CA1461	W 20040804

ASSIGNMENT HISTORY FOR US PATENT AVAILABLE IN LSUS DISPLAY FORMAT

AB The crosslinked polyether is obtained by polymerization of ≥ 1 monomer selected from the group consisting of (a) (α -X-methyl) vinyl-electron withdrawing group (EWG), (α -X-methyl) vinyl-electron releasing group (ERG), or (α -X-methyl) vinyl-aryl, where X = O, S, polyethylene glycol (PEG), polypropylene glycol (PPG) or poly(THF), (b) a monomer polymerizable with a PEG, PPG or poly(THF) crosslinker having ≥ 1 (α -X-methyl) vinyl-EWG, (α -X-methyl) vinyl-ERG or (α -X-methyl) vinyl-aryl, where X = O, S, PEG, PPG, or poly(THF), (c) a PEG, PPG, or

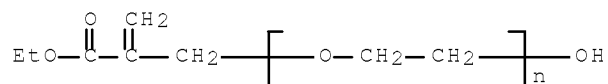
poly(THF) crosslinker having at least an acrylamide or a methacrylamide end group, and (d) mixts.

IT 183892-60-6P

(highly crosslinked terminally functional polyethylene glycols)

RN 183892-60-6 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-(ethoxycarbonyl)-2-propenyl]- ω -hydroxy- (9CI) (CA INDEX NAME)

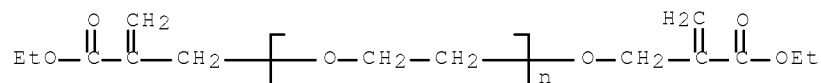


IT 333305-83-2P

(preparation and radical crosslinking, end group reduction or hydrolysis, bromination)

RN 333305-83-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(3-ethoxy-2-methylene-3-oxopropyl)- ω -(3-ethoxy-2-methylene-3-oxopropoxy)- (9CI) (CA INDEX NAME)



IC ICM C07D0305-14

ICS C08G0065-02; C08F0261-06; C08F0283-00; C08F0002-18; C08J0003-24; C08F0016-12

CC 37-3 (Plastics Manufacture and Processing)

Section cross-reference(s): 34

ST polyethylene glycol vinyl group terminated

IT Polyoxyalkylenes, preparation

(highly crosslinked terminally functional polyethylene glycols)

IT Polymer-supported reagents

Solid phase synthesis

(highly crosslinked terminally functional polyethylene glycols for)

IT 183892-60-6P 838839-63-7P 838839-64-8P

(highly crosslinked terminally functional polyethylene glycols)

IT 333305-83-2P

(preparation and radical crosslinking, end group reduction or hydrolysis, bromination)

IT 68858-20-8

(reaction with Wang type resin based on functional polyethylene glycols; highly crosslinked terminally functional polyethylene glycols)

RETABLE

Referenced Author (RAU)	Year (RPY)	VOL (RVL)	PG (RPG)	Referenced Work (RWK)	Referenced File
=====	=====	=====	=====	=====	=====
Cote, S	2002			WO 0240559 A	HCAPLUS
Hayashi, K	1994			EP 692501 A	HCAPLUS

June 18, 2010

10/567,430

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Kempe	1999		US 5910554	HCAPLUS
Satake, Y	2001		EP 1288272 A	HCAPLUS
Snyder, J	1995		EP 633912	HCAPLUS
Soderman, T	2003		WO 2003102040 A	
Sunkara, H	2004		WO 2004014984	HCAPLUS
Trofimov, B	1999		WO 9964484 A	HCAPLUS

OS.CITING REF COUNT: 13 THERE ARE 13 CAPLUS RECORDS THAT CITE THIS
RECORD (16 CITINGS)

=> D L50 1-15 IBIB ABS HITSTR HITIND RETABLE

L50 ANSWER 1 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN
 ACCESSION NUMBER: 2008:582915 HCAPLUS Full-text
 DOCUMENT NUMBER: 148:540382
 TITLE: Amino-and polyoxyalkylene-containing
 acrylic acid-based emulsifiers for vinyl
 polymerization and vinyl polymers manufactured
 using them
 INVENTOR(S): Katsukawa, Yoshitaka
 PATENT ASSIGNEE(S): Sanyo Chemical Industries, Ltd., Japan
 SOURCE: Jpn. Kokai Tokkyo Koho, 11pp.
 CODEN: JKXXAF
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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JP 2008111031	A	20080515	JP 2006-294543	20061030
			<--	
PRIORITY APPLN. INFO.:			JP 2006-294543	20061030
			<--	

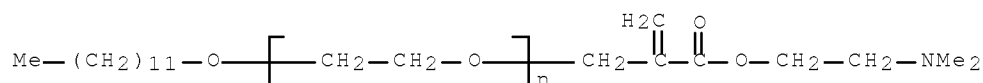
OTHER SOURCE(S): MARPAT 148:540382

AB The invention relates to the emulsifiers CH₂:C(CO₂R₂NR₃R₄)CH₂O(AO)_nR₁ (I; R₁ = C₁-24 hydrocarbon; R₂ = C₁-8 alkylene; R₃, R₄ = C₁-4 alkyl; A = C₂-4 alkylene; n = 1-200). Tertiary amine salt-type emulsifiers prepared from I and acids, and quaternary ammonium salt-type emulsifiers prepared from I and quaternizing agents are also claimed. Thus, Me acrylate was reacted with formaldehyde, PBr₃, ethoxylated dodecyl alc., and dimethylaminoethanol to give I (R₁ = dodecyl, R₂ = CH₂CH₂, R₃ = R₄ = Me, A = CH₂, n = 8). Bu acrylate, methacrylic acid, and Me methacrylate was emulsion-polymerized in the presence of I and neutralized with NH₃ to give an emulsion with monomer conversion 98% and good antifoaming properties, which was then applied on a substrate and dried to give a test piece with good water resistance.

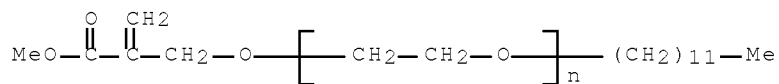
IT 1025111-51-6DP, salts with acids
 (amino-and polyoxyalkylene-containing acrylic acid-based
 emulsifiers used in vinyl polymerization for water-resistant coatings)

RN 1025111-51-6 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α-[2-[[2-
 (dimethylamino)ethoxy]carbonyl]-2-propen-1-yl]-ω-(dodecyloxy)-
 (CA INDEX NAME)



IT 1025111-49-2P
 (amino-and polyoxyalkylene-containing acrylic acid-based
 emulsifiers used in vinyl polymerization for water-resistant coatings)
 RN 1025111-49-2 HCAPLUS
 CN Poly(oxy-1,2-ethanediyl), α -dodecyl- ω -[[2-
 (methoxycarbonyl)-2-propen-1-yl]oxy]- (CA INDEX NAME)



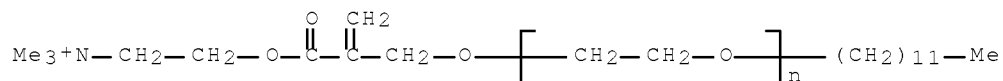
IT 1025111-54-9P
 (emulsifier; amino-and polyoxyalkylene-containing acrylic
 acid-based emulsifiers used in vinyl polymerization for water-resistant
 coatings)
 RN 1025111-54-9 HCAPLUS
 CN Poly(oxy-1,2-ethanediyl), α -dodecyl- ω -[[2-[[2-
 (trimethylammonio)ethoxy]carbonyl]-2-propen-1-yl]oxy]-, methyl sulfate
 (1:1) (CA INDEX NAME)

CM 1

CRN 1025111-53-8

CMF (C2 H4 O)_n C21 H42 N O3

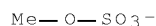
CCI PMS



CM 2

CRN 21228-90-0

CMF C H3 O4 S



CC 46-4 (Surface Active Agents and Detergents)
 Section cross-reference(s): 37
 ST amino polyoxyalkylene acrylate emulsifier vinyl polymn;
 acrylate based emulsifier water resistant coating; emulsifier emulsion
 polymn antifoaming vinyl polymer
 IT Emulsifying agents
 (amino-and polyoxyalkylene-containing acrylic acid-based
 emulsifiers used in vinyl polymerization for water-resistant coatings)
 IT Polymerization
 (emulsion; amino-and polyoxyalkylene-containing acrylic

- acid-based emulsifiers used in vinyl polymerization for water-resistant coatings)
- IT 42884-82-2P, Butyl acrylate-methacrylic acid-methyl methacrylate copolymer ammonium salt
(amino-and polyoxyalkylene-containing acrylic acid-based emulsifiers used in vinyl polymerization for water-resistant coatings)
- IT 1025111-51-6DP, salts with acids
(amino-and polyoxyalkylene-containing acrylic acid-based emulsifiers used in vinyl polymerization for water-resistant coatings)
- IT 4224-69-5P, Methyl α -(bromomethyl)acrylate 15484-46-5P, Methyl α -(hydroxymethyl)acrylate 1025111-49-2P
(amino-and polyoxyalkylene-containing acrylic acid-based emulsifiers used in vinyl polymerization for water-resistant coatings)
- IT 50-00-0, Formaldehyde, reactions 77-78-1, Dimethylsulfate 96-33-3, Methyl acrylate 108-01-0, Dimethylaminoethanol 9002-92-0, Ethoxylated dodecyl alcohol
(amino-and polyoxyalkylene-containing acrylic acid-based emulsifiers used in vinyl polymerization for water-resistant coatings)
- IT 7789-60-8, Phosphorous tribromide
(amino-and polyoxyalkylene-containing acrylic acid-based emulsifiers used in vinyl polymerization for water-resistant coatings)
- IT 1025111-54-9P
(emulsifier; amino-and polyoxyalkylene-containing acrylic acid-based emulsifiers used in vinyl polymerization for water-resistant coatings)

L50 ANSWER 2 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2007:640655 HCAPLUS Full-text

DOCUMENT NUMBER: 147:74721

TITLE: Alkali metal-free surfactants containing carboxybetaines and amines, and cleaners containing them

INVENTOR(S): Sakurai, Kenichi

PATENT ASSIGNEE(S): Sanyo Chemical Industries, Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 27pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2007146025	A	20070614	JP 2005-343436	20051129

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PRIORITY APPLN. INFO.: JP 2005-315694 A 20051031

<--

OTHER SOURCE(S): MARPAT 147:74721

AB The surfactants contain R1(OA)nOCH2CH(CO2-)CH2N+R23 (R1, R2 = H, C1-22 organic group; OA = C2-4 oxyalkylene; n = 0-200), amines having change in heat of formation 10-152 kcal/mol by protonation, and optionally N+R3R4R5R6OH- (R3-R6 = C1-24 hydrocarbyl, (R7O)pH; R7 = C2-4 alkylene; p = 1-6) and polyhydric alcs. Also claimed is manufacture of electronic materials and parts, e.g., liquid crystal display panels, semiconductor chips, by cleaning with the cleaners. Thus, a Si wafer (the number of deposited particles >10,000) was soaked in a cleaner containing 3-trimethylammonio-2-hexadecyloxymethyl propionate and DBU at 20° for 20 min, showing the number of deposited particles 70.

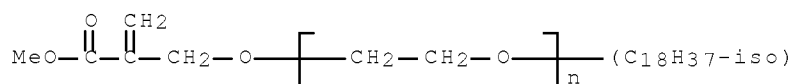
IT 940935-15-9P

(surfactants containing carboxybetaines and amines for cleaning of liquid

crystal display panels and semiconductor chips)

RN 940935-15-9 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -isooctadecyl- ω -[[2-(methoxycarbonyl)-2-propen-1-yl]oxy]- (CA INDEX NAME)



CC 46-6 (Surface Active Agents and Detergents)

Section cross-reference(s): 74, 76

IT Polyoxyalkylenes

(carboxybetaines; surfactants containing carboxybetaines and amines for cleaning of liquid crystal display panels and semiconductor chips)

IT 4224-69-5P, Methyl α -bromomethylacrylate 15484-46-5P, Methyl

α -hydroxymethylacrylate 940927-06-0P 940935-15-9P

(surfactants containing carboxybetaines and amines for cleaning of liquid crystal display panels and semiconductor chips)

L50 ANSWER 3 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2006:541060 HCAPLUS Full-text

DOCUMENT NUMBER: 145:33502

TITLE: Carboxybetaines with improved moisturizing properties, their preparation, and moisturizers and cosmetics containing them

INVENTOR(S): Sakurai, Kenichi

PATENT ASSIGNEE(S): Sanyo Chemical Industries, Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 18 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2006143634	A	20060608	JP 2004-334376	20041118

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PRIORITY APPLN. INFO.: JP 2004-334376 20041118

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AB The carboxybetaines, useful for amphoteric surfactants, are depicted as $\text{R1}_2\text{N}^+(\text{R3CO}_2^-)\text{R2}[\text{N}+\text{R1}(\text{R3CO}_2^-)\text{R2}]_m\text{N1R1}_2(\text{R3CO}_2^-)$ [R1 = C1-22 organic group; R2 = C1-8 organic group; R3 = methylene, CH_2CHR_4 ; R4 = H, Me; $\text{R5}(\text{AO})_n\text{OCH}_2$; R5 = H, C1-22 organic group; AO = C2-4 oxyalkylene; n = 0-200; m = 0-6]. Thus, an aqueous solution of 5% N,N'-dimethyl-N,N'-dipropylethylenediammoniodipropionate, prepared by quaternizing Na N,N'-dipropyl-3,3'-(ethylenediimino)dipropionate with MeCl, showed good initial moisturizing properties and moisture retention on skins.

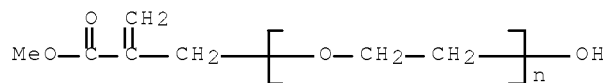
IT 198488-74-3P, Methyl

α -[hydroxyethyl(polyoxyethylene)oxymethyl]acrylate

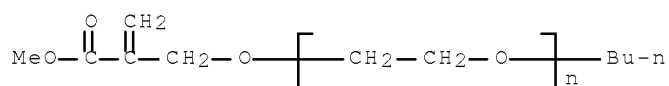
(aminocarboxylic acid from; preparation of carboxybetaines for cosmetics with improved moisturizing properties)

RN 198488-74-3 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-(methoxycarbonyl)-2-propenyl]- ω -hydroxy- (9CI) (CA INDEX NAME)



- IT 318234-53-6P, Methyl
 α -[butoxyethyl (polyoxyethylene)oxymethyl]acrylate
 (for aminocarboxyl compound preparation; preparation of carboxybetaines for cosmetics with improved moisturizing properties)
- RN 318234-53-6 HCAPLUS
- CN Poly(oxy-1,2-ethanediyl), α -butyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]- (9CI) (CA INDEX NAME)



- CC 62-4 (Essential Oils and Cosmetics)
- IT Polyoxyalkylenes, biological studies
 (betaines; preparation of carboxybetaines for cosmetics with improved moisturizing properties)
- IT 198488-74-3P, Methyl
 α -[hydroxyethyl (polyoxyethylene)oxymethyl]acrylate
 (aminocarboxylic acid from; preparation of carboxybetaines for cosmetics with improved moisturizing properties)
- IT 15484-46-5P, Methyl α -hydroxymethylacrylate 17361-75-0P,
 N,N'-Dipropylethylenediamine 23873-54-3P,
 α -Hydroxymethylacrylonitrile 68555-41-9P,
 N,N,N',N'-Tetrapropylethylenediamine 318234-53-6P, Methyl
 α -[butoxyethyl (polyoxyethylene)oxymethyl]acrylate 318234-90-1P
 747345-59-1P, N,N'-Dimethyl-N,N'-dipropylethylenediamine
 876908-49-5P, α -
 [Hydroxyethyl (polyoxyethylene)oxymethyl]acrylonitrile
 (for aminocarboxyl compound preparation; preparation of carboxybetaines for cosmetics with improved moisturizing properties)
- IT 50-00-0, Formaldehyde, reactions 75-21-8, Ethylene oxide, reactions
 96-33-3, Methyl acrylate 107-13-1, Acrylonitrile, reactions
 9004-77-7, Polyethylene glycol monobutyl ether
 (for vinyl compound preparation; preparation of carboxybetaines for cosmetics with improved moisturizing properties)

L50 ANSWER 4 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN
 ACCESSION NUMBER: 2006:541058 HCAPLUS Full-text
 DOCUMENT NUMBER: 145:33501
 TITLE: Aminocarboxylic acids, their preparation, and
 detergents containing them for leaving
 moisturizing feelings to skins
 INVENTOR(S): Sakurai, Kenichi
 PATENT ASSIGNEE(S): Sanyo Chemical Industries, Ltd., Japan
 SOURCE: Jpn. Kokai Tokyo Koho, 14 pp.
 CODEN: JKXXAF
 DOCUMENT TYPE: Patent

June 18, 2010

10/567,430

12

LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2006143633	A	20060608	JP 2004-334375	20041118
			<--	
PRIORITY APPLN. INFO.:			JP 2004-334375	20041118
			<--	

OTHER SOURCE(S): MARPAT 145:33501

AB The compds., useful for amphoteric surfactants, are depicted as
 $R_1N(CH_2CHR_3CO_2M)R_2[N(CH_2CHR_3CO_2M)R_2]_mNR_1CH_2CHR_3CO_2M$ [R_1 = C1-22 organic group;
 R_2 = C1-8 organic group; R_3 = H, Me, $R_3(AO)_nOCH_2$; R_4 = H, C1-22 organic group;
 AO = C2-4 oxyalkylene; n = 0-200; M = H, metal, ammonium; m = 0-6]. Thus, a
 cleansing agent containing N,N'-dipropyl-3,3'-(ethylenediimino)dipropionic
 acid (prepared from N,N'-dipropylethylenediamine and acrylic acid) showed good
 foaming stability and left no sliminess or tautness to skins after cleansing.

IT 198488-74-3P, Methyl

α -[hydroxyethyl(polyoxyethylene)oxymethyl]acrylate

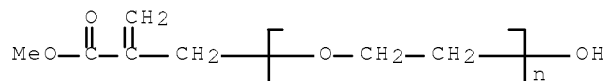
318234-53-6P, Methyl α -

[butoxyethyl(polyoxyethylene)oxymethyl]acrylate

(aminocarboxylic acid from; preparation of aminocarboxylic acids from
 vinyl compds. and polyamines for amphoteric surfactants for
 skin-cleaning detergents leaving moisturizing feelings to skins)

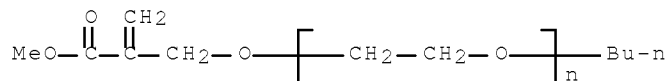
RN 198488-74-3 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-(methoxycarbonyl)-2-propenyl]-
 ω -hydroxy- (9CI) (CA INDEX NAME)



RN 318234-53-6 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -butyl- ω -[[2-(methoxycarbonyl)-
 2-propenyl]oxy]- (9CI) (CA INDEX NAME)



CC 62-4 (Essential Oils and Cosmetics)

Section cross-reference(s): 46

IT Polyoxyalkylenes, biological studies

(amine- and carboxyl-containing; preparation of aminocarboxylic acids from
 vinyl compds. and polyamines for amphoteric surfactants for
 skin-cleaning detergents leaving moisturizing feelings to skins)

IT 15484-46-5P, Methyl α -hydroxymethylacrylate 17361-75-0P,

N,N'-Dipropylethylenediamine 23873-54-3P,

α -Hydroxymethylacrylonitrile 198488-74-3P, Methyl

α -[hydroxyethyl(polyoxyethylene)oxymethyl]acrylate

318234-53-6P, Methyl α -

[butoxyethyl (polyoxyethylene)oxymethyl]acrylate 318234-90-1P

876908-49-5P, α -

[Hydroxyethyl (polyoxyethylene)oxymethyl]acrylonitrile

(aminocarboxylic acid from; preparation of aminocarboxylic acids from vinyl compds. and polyamines for amphoteric surfactants for skin-cleaning detergents leaving moisturizing feelings to skins)

IT 50-00-0, Formaldehyde, reactions 75-21-8, Ethylene oxide, reactions

96-33-3, Methyl acrylate 107-13-1, Acrylonitrile, reactions

9004-77-7, Polyethylene glycol monobutyl ether

(for vinyl compound preparation; preparation of aminocarboxylic acids from vinyl compds. and polyamines for amphoteric surfactants for skin-cleaning detergents leaving moisturizing feelings to skins)

L50 ANSWER 5 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2006:190641 HCAPLUS Full-text

DOCUMENT NUMBER: 144:254964

TITLE: ~~Polyoxyalkylene~~ chain-containing vinyl monomers and their polymers

INVENTOR(S): Sakurai, Kenichi

PATENT ASSIGNEE(S): Sanyo Chemical Industries Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 16 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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JP 2006057040	A	20060302	JP 2004-242110	20040823

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PRIORITY APPLN. INFO.: JP 2004-242110 20040823

<--

AB The monomers which are scarcely hydrolyzed, are represented by $R(OA)_nOCH_2CHX:CH_2$ ($OA = C_2-4$ oxyalkylene; $n = 1-200$; $X = CO_2H, CO_2R', CO_2M, CO_2NR'_4, CONR'_2, CN$; $M = metal$; $R, R' = H, C_1-6$ org). The polymers for coating binders, adhesives, dispersants, cement additives, scale inhibitors, thickeners, flocculants, etc., contain the monomers and optionally (meth)acrylic acids or their salts. Thus, Me α -hydroxymethylacrylate [prepared from Me acrylate and HCHO] was reacted with ethylene oxide to give a polyoxyethylene chain-containing monomer, which was polymerized with acrylic acid and then neutralized with NaOH to give a water-soluble vinyl polymer showing good mortar dispersibility even after 2 mo-storage.

IT 877071-00-6P, Acrylic acid-polyethylene glycol

monoether with methyl α -hydroxymethylacrylate graft copolymer

sodium salt 877071-03-9P, Acrylic

acid-N,N-dimethyl- α -

[hydroxyethyl (polyoxyethylene)oxymethyl]acrylamide graft copolymer

sodium salt 877071-04-0P, Acrylic acid-polyethylene

glycol butyl ether methyl α -hydroxymethylacrylate ether

graft copolymer sodium salt 877071-06-2P, Acrylic

acid-N,N-dimethyl- α -

butoxyethyl (polyoxyethylene)oxymethylacrylamide graft copolymer sodium salt

(cement additive; ~~polyoxyalkylene~~ chain-containing vinyl monomers and their polymers with high hydrolysis resistance)

RN 877071-00-6 HCAPLUS

CN 2-Propenoic acid, polymer with

α -[2-(methoxycarbonyl)-2-propenyl]- ω -hydroxypoly(oxy-1,2-

ethanediyl), graft, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 876596-51-9

CMF (C3 H4 O2 . (C2 H4 O)n C5 H8 O3)x

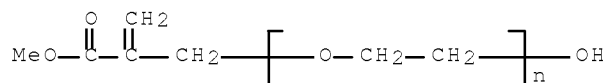
CCI PMS

CM 2

CRN 198488-74-3

CMF (C2 H4 O)n C5 H8 O3

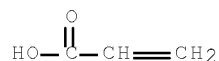
CCI PMS



CM 3

CRN 79-10-7

CMF C3 H4 O2



RN 877071-03-9 HCAPLUS

CN 2-Propenoic acid, polymer with

α -[2-[(dimethylamino)carbonyl]-2-propenyl]- ω -

hydroxypoly(oxy-1,2-ethanediyl), graft, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 876596-55-3

CMF (C3 H4 O2 . (C2 H4 O)n C6 H11 N O2)x

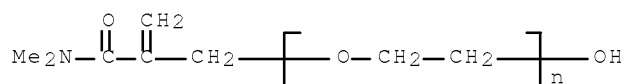
CCI PMS

CM 2

CRN 876596-54-2

CMF (C2 H4 O)n C6 H11 N O2

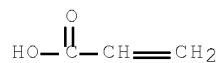
CCI PMS



CM 3

CRN 79-10-7

CMF C3 H4 O2



RN 877071-04-0 HCAPLUS

CN 2-Propenoic acid, polymer with

α -butyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]poly(oxy-1,2-ethanediyl), graft, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 876596-56-4

CMF (C3 H4 O2 . (C2 H4 O)n C9 H16 O3)x

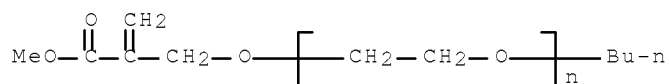
CCI PMS

CM 2

CRN 318234-53-6

CMF (C2 H4 O)n C9 H16 O3

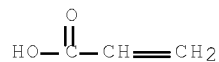
CCI PMS



CM 3

CRN 79-10-7

CMF C3 H4 O2



RN 877071-06-2 HCAPLUS

CN 2-Propenoic acid, polymer with

α -butyl- ω -[2-[(dimethylamino)carbonyl]-2-propenyl]poly(oxy-1,2-ethanediyl), graft, sodium salt (9CI) (CA INDEX NAME)

CM 1

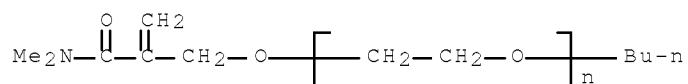
CRN 876596-58-6

CMF (C3 H4 O2 . (C2 H4 O)n C10 H19 N O2)x

CCI PMS

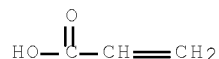
CM 2

CRN 876596-57-5
 CMF (C2 H4 O)_n C10 H19 N O2
 CCI PMS



CM 3

CRN 79-10-7
 CMF C3 H4 O2



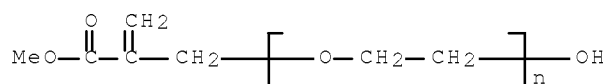
IT 877071-09-5P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-polyethylene glycol monoether with methyl α -hydroxymethylacrylate graft copolymer 877071-11-9P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-N,N-dimethyl- α -[hydroxyethyl(polyoxyethylene)oxymethyl]acrylamide graft copolymer 877071-12-0P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-polyethylene glycol butyl ether methyl α -hydroxymethylacrylate ether graft copolymer 877071-14-2P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-N,N-dimethyl- α -butoxyethyl(polyoxyethylene)oxymethylacrylamide graft copolymer (flocculant; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)

RN 877071-09-5 HCAPLUS

CN Ethanaminium, N,N,N-trimethyl-2-[(1-oxo-2-propenyl)oxy]-, chloride, polymer with α -[2-(methoxycarbonyl)-2-propenyl]- ω -hydroxypoly(oxy-1,2-ethanediyl) and 2-propenamide, graft (9CI) (CA INDEX NAME)

CM 1

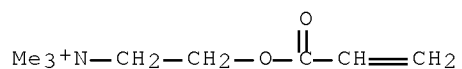
CRN 198488-74-3
 CMF (C2 H4 O)_n C5 H8 O3
 CCI PMS



CM 2

CRN 44992-01-0

CMF C8 H16 N O2 . Cl



CM 3

CRN 79-06-1

CMF C3 H5 N O



RN 877071-11-9 HCAPLUS

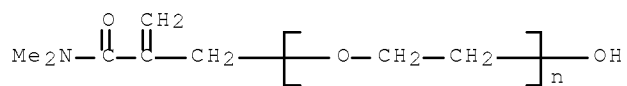
CN Ethanaminium, N,N,N-trimethyl-2-[(1-oxo-2-propenyl)oxy]-, chloride, polymer with α -[2-[(dimethylamino)carbonyl]-2-propenyl]- ω -hydroxypoly(oxy-1,2-ethanediyl) and 2-propenamide, graft (9CI) (CA INDEX NAME)

CM 1

CRN 876596-54-2

CMF (C2 H4 O)_n C6 H11 N O2

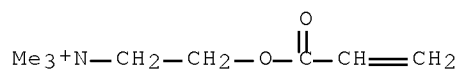
CCI PMS



CM 2

CRN 44992-01-0

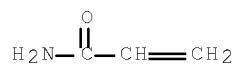
CMF C8 H16 N O2 . Cl



CM 3

CRN 79-06-1

CMF C3 H5 N O



RN 877071-12-0 HCAPLUS

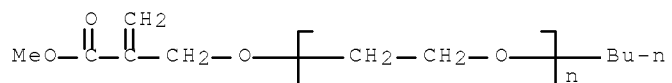
CN Ethanaminium, N,N,N-trimethyl-2-[(1-oxo-2-propenyl)oxy]-, chloride, polymer with α -butyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]poly(oxy-1,2-ethanediyl) and 2-propenamide, graft (9CI) (CA INDEX NAME)

CM 1

CRN 318234-53-6

CMF (C2 H4 O)_n C9 H16 O3

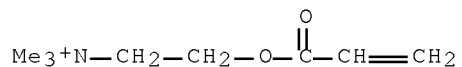
CCI PMS



CM 2

CRN 44992-01-0

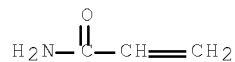
CMF C8 H16 N O2 . Cl



CM 3

CRN 79-06-1

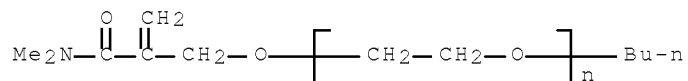
CMF C3 H5 N O



RN 877071-14-2 HCAPLUS
 CN Ethanaminium, N,N,N-trimethyl-2-[(1-oxo-2-propenyl)oxy]-, chloride, polymer with α -butyl- ω -[[2-[(dimethylamino)carbonyl]-2-propenyl]oxy]poly(oxy-1,2-ethanediyl) and 2-propenamide, graft (9CI) (CA INDEX NAME)

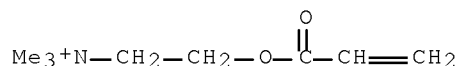
CM 1

CRN 876596-57-5
 CMF (C2 H4 O)_n C10 H19 N O2
 CCI PMS



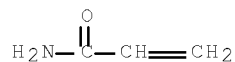
CM 2

CRN 44992-01-0
 CMF C8 H16 N O2 . Cl

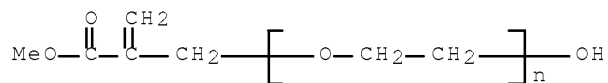


CM 3

CRN 79-06-1
 CMF C3 H5 N O

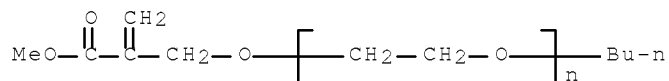


IT 198488-74-3P, Polyethylene glycol monoether with methyl α -hydroxymethylacrylate 318234-53-6P, Polyethylene glycol butyl ether methyl α -hydroxymethylacrylate ether 876596-54-2P, N,N-Dimethyl- α -[hydroxyethyl(polyoxyethylene)oxymethyl]acrylamide 876596-57-5P (macromonomer; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)
 RN 198488-74-3 HCAPLUS
 CN Poly(oxy-1,2-ethanediyl), α -[2-(methoxycarbonyl)-2-propenyl]- ω -hydroxy- (9CI) (CA INDEX NAME)



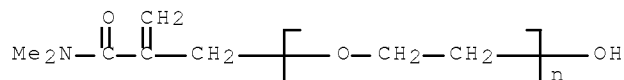
RN 318234-53-6 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -butyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]- (9CI) (CA INDEX NAME)



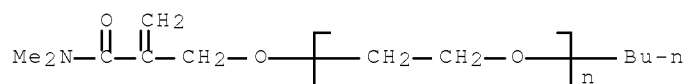
RN 876596-54-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-[(dimethylamino)carbonyl]-2-propenyl]- ω -hydroxy- (9CI) (CA INDEX NAME)



RN 876596-57-5 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -butyl- ω -[[2-[(dimethylamino)carbonyl]-2-propenyl]oxy]- (9CI) (CA INDEX NAME)



IT 877071-18-6P, Acrylic acid-pentaerythritol triallyl ether-polyethylene glycol monoether with methyl α -hydroxymethylacrylate copolymer sodium salt
 877071-22-2P, Acrylic acid-N,N-dimethyl- α -[hydroxyethyl(polyoxyethylene)oxymethyl]acrylamide-pentaerythritol triallyl ether copolymer sodium salt 877071-24-4P, Acrylic acid-pentaerythritol triallyl ether-polyethylene glycol butyl ether methyl α -hydroxymethylacrylate ether copolymer sodium salt 877071-28-8P, Acrylic acid-N,N-dimethyl- α -butoxyethyl(polyoxyethylene)oxymethylacrylamide-pentaerythritol triallyl ether copolymer sodium salt
 (water absorbent; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)

RN 877071-18-6 HCAPLUS

CN 2-Propenoic acid, polymer with α -[2-(methoxycarbonyl)-2-propenyl]- ω -hydroxypoly(oxy-1,2-ethanediyl) and 3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-

propanol, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 877071-17-5

CMF (C14 H24 O4 . C3 H4 O2 . (C2 H4 O)n C5 H8 O3)x

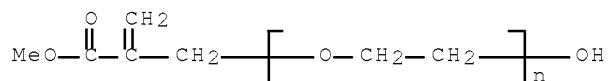
CCI PMS

CM 2

CRN 198488-74-3

CMF (C2 H4 O)n C5 H8 O3

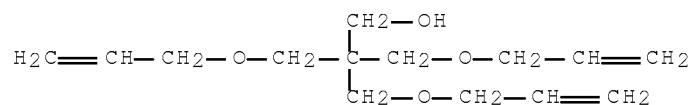
CCI PMS



CM 3

CRN 1471-17-6

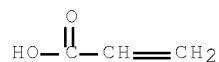
CMF C14 H24 O4



CM 4

CRN 79-10-7

CMF C3 H4 O2



RN 877071-22-2 HCAPLUS

CN 2-Propenoic acid, polymer with

α -[2-[(dimethylamino)carbonyl]-2-propenyl]- ω -

hydroxypoly(oxy-1,2-ethanediyl) and

3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-propanol, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 877071-21-1

CMF (C14 H24 O4 . C3 H4 O2 . (C2 H4 O)n C6 H11 N O2)x

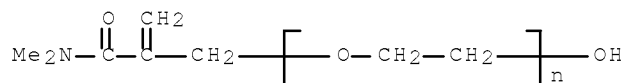
CCI PMS

CM 2

CRN 876596-54-2

CMF (C2 H4 O)_n C6 H11 N O2

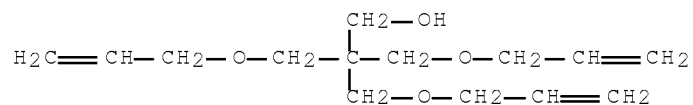
CCI PMS



CM 3

CRN 1471-17-6

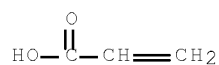
CMF C14 H24 O4



CM 4

CRN 79-10-7

CMF C3 H4 O2



RN 877071-24-4 HCAPLUS

CN 2-Propenoic acid, polymer with

α -butyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]poly(oxy-1,2-ethanediyl) and 3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-propanol, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 877071-23-3

CMF (C14 H24 O4 . C3 H4 O2 . (C2 H4 O)_n C9 H16 O3)_x

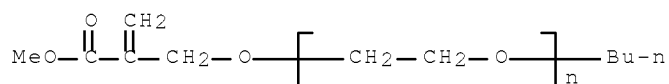
CCI PMS

CM 2

CRN 318234-53-6

CMF (C2 H4 O)_n C9 H16 O3

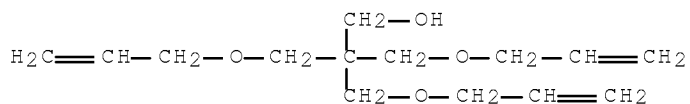
CCI PMS



CM 3

CRN 1471-17-6

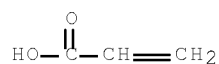
CMF C14 H24 O4



CM 4

CRN 79-10-7

CMF C3 H4 O2



RN 877071-28-8 HCAPLUS

CN 2-Propenoic acid, polymer with

α -butyl- ω -[[2-[(dimethylamino)carbonyl]-2-propenyl]oxy]poly(oxy-1,2-ethanediyl) and

3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-propanol, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 877071-27-7

CMF (C14 H24 O4 . C3 H4 O2 . (C2 H4 O)_n C10 H19 N O2)_x

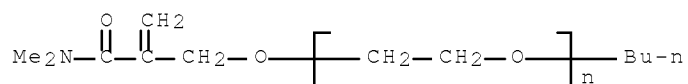
CCI PMS

CM 2

CRN 876596-57-5

CMF (C2 H4 O)_n C10 H19 N O2

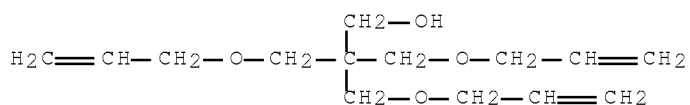
CCI PMS



CM 3

CRN 1471-17-6

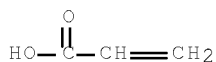
CMF C14 H24 O4



CM 4

CRN 79-10-7

CMF C3 H4 O2



- CC 37-3 (Plastics Manufacture and Processing)
Section cross-reference(s): 35, 38, 58, 60
- ST polyoxyalkylene chain vinyl monomer polymer hydrolysis
resistance; acrylic polyoxyethylene cement additive sludge flocculant
water absorbent; polyethylene glycol hydroxymethylacrylate
ether macromer acrylic acid copolymer
- IT Polyoxyalkylenes, preparation
(acrylic, graft; polyoxyalkylene chain-containing vinyl
monomers and their polymers with high hydrolysis resistance)
- IT Macromonomers
(polyoxyalkylene chain-containing vinyl monomers and their
polymers with high hydrolysis resistance)
- IT Cement
(vinyl polymer additive for; polyoxyalkylene chain-containing
vinyl monomers and their polymers with high hydrolysis resistance)
- IT Flocculants
Polyelectrolytes
(vinyl polymer for; polyoxyalkylene chain-containing vinyl
monomers and their polymers with high hydrolysis resistance)
- IT Absorbents
(water, vinyl polymer for; polyoxyalkylene chain-containing
vinyl monomers and their polymers with high hydrolysis resistance)
- IT 167763-00-0P, Acrylic acid-ethylene oxide graft copolymer sodium salt
288371-11-9P, Acrylic acid-ethylene oxide graft copolymer butyl ether
sodium salt 877071-00-6P, Acrylic acid-polyethylene
glycol monoether with methyl α -hydroxymethylacrylate
graft copolymer sodium salt 877071-02-8P, Acrylic acid-polyethylene
glycol monoether with α -hydroxymethylacrylonitrile graft
copolymer sodium salt 877071-03-9P, Acrylic
acid-N,N-dimethyl- α -
[hydroxyethyl(polyoxyethylene)oxymethyl]acrylamide graft copolymer
sodium salt 877071-04-0P, Acrylic acid-polyethylene
glycol butyl ether methyl α -hydroxymethylacrylate ether
graft copolymer sodium salt 877071-05-1P, Acrylic

- acid- α -butoxyethyl (polyoxyethylene)oxymethylacrylonitrile graft copolymer sodium salt 877071-06-2P, Acrylic acid-N,N-dimethyl- α -butoxyethyl (polyoxyethylene)oxymethylacrylamide graft copolymer sodium salt 877071-07-3P, Acrylic acid-polyethylene glycol mono(2-carboxy-2-propenyl) ether sodium salt graft copolymer sodium salt 877071-08-4P, Acrylic acid-polyethylene glycol butyl 2-carboxy-2-propenyl ether sodium salt graft copolymer sodium salt (cement additive; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)
- IT 591219-65-7P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-ethylene oxide graft copolymer 877071-09-5P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-polyethylene glycol monoether with methyl α -hydroxymethylacrylate graft copolymer 877071-10-8P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-polyethylene glycol monoether with α -hydroxymethylacrylonitrile graft copolymer 877071-11-9P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-N,N-dimethyl- α -[hydroxyethyl (polyoxyethylene)oxymethyl]acrylamide graft copolymer 877071-12-0P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-polyethylene glycol butyl ether methyl α -hydroxymethylacrylate ether graft copolymer 877071-13-1P 877071-14-2P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-N,N-dimethyl- α -butoxyethyl (polyoxyethylene)oxymethylacrylamide graft copolymer 877071-15-3P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-polyethylene glycol mono(2-carboxy-2-propenyl) ether sodium salt graft copolymer 877071-16-4P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-polyethylene glycol butyl 2-carboxy-2-propenyl ether sodium salt graft copolymer 877117-69-6P, Acrylamide-acryloyloxyethyltrimethylammonium chloride-ethylene oxide graft copolymer butyl ether (flocculant; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)
- IT 4224-69-5P, Methyl α -bromomethylacrylate 15484-46-5P, Methyl α -hydroxymethylacrylate 23873-54-3P, α -Hydroxymethylacrylonitrile 876908-50-8P, N,N-Dimethyl- α -hydroxymethylacrylamide (macromonomer from; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)
- IT 50-00-0, Formaldehyde, reactions 75-21-8, Ethylene oxide, reactions 96-33-3, Methyl acrylate 107-13-1, Acrylonitrile, reactions 2680-03-7, N,N-Dimethylacrylamide 7789-60-8, Phosphorus tribromide 9004-77-7, Polyethylene glycol butyl ether (macromonomer from; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)
- IT 183892-71-9P 198488-74-3P, Polyethylene glycol monoether with methyl α -hydroxymethylacrylate 318234-53-6P, Polyethylene glycol butyl ether methyl α -hydroxymethylacrylate ether 876596-52-0P, α -Butoxyethyl (polyoxyethylene)oxymethylacrylonitrile 876596-54-2P, N,N-Dimethyl- α -[hydroxyethyl (polyoxyethylene)oxymethyl]acrylamide 876596-57-5P 876596-60-0P 876908-49-5P, Polyethylene glycol monoether with α -hydroxymethylacrylonitrile

(macromonomer; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)

IT 877071-18-6P, Acrylic acid-pentaerythritol triallyl ether-polyethylene glycol monoether with methyl α -hydroxymethylacrylate copolymer sodium salt 877071-20-0P, Acrylic acid-pentaerythritol triallyl ether-polyethylene glycol monoether with α -hydroxymethylacrylonitrile copolymer sodium salt 877071-22-2P, Acrylic acid-N,N-dimethyl- α -[hydroxyethyl(polyoxyethylene)oxymethyl]acrylamide-pentaerythritol triallyl ether copolymer sodium salt 877071-24-4P, Acrylic acid-pentaerythritol triallyl ether-polyethylene glycol butyl ether methyl α -hydroxymethylacrylate ether copolymer sodium salt 877071-26-6P, Acrylic acid- α -butoxyethyl(polyoxyethylene)oxymethylacrylonitrile-pentaerythritol triallyl ether copolymer sodium salt 877071-28-8P, Acrylic acid-N,N-dimethyl- α -butoxyethyl(polyoxyethylene)oxymethylacrylamide-pentaerythritol triallyl ether copolymer sodium salt 877071-30-2P, Acrylic acid-pentaerythritol triallyl ether-polyethylene glycol mono(2-carboxy-2-propenyl) ether sodium salt copolymer sodium salt 877071-32-4P, Acrylic acid-pentaerythritol triallyl ether-polyethylene glycol butyl 2-carboxy-2-propenyl ether sodium saltt copolymer sodium salt

(water absorbent; polyoxyalkylene chain-containing vinyl monomers and their polymers with high hydrolysis resistance)

L50 ANSWER 6 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2006:190639 HCAPLUS Full-text

DOCUMENT NUMBER: 144:255320

TITLE: Water-absorbing acrylic polymers with high gel modulus and water absorbents containing them

INVENTOR(S): Sakurai, Kenichi

PATENT ASSIGNEE(S): Sanyo Chemical Industries Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 10 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2006057039	A	20060302	JP 2004-242107	20040823

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PRIORITY APPLN. INFO.: JP 2004-242107 20040823

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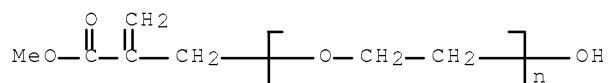
AB Title polymers, suitable for sanitary goods, etc., contain units from vinyl monomers R(OA)nOCH₂CHX:CH₂ (OA = C₂-4 oxyalkylene; n = 1-200; X = CO₂H, CO₂R', CO₂M, CO₂NR', CONR'₂, CN; M = metal; R, R' = H, C₁-6 organic group) and optionally (meth)acrylic acid (salt) units. Thus, ethylene oxide was added dropwise to Me α -(hydroxymethyl)acrylate (I; manufactured by treating Me acrylate with HCHO) to obtain polyethylene glycol monoether of I, which was polymerized with acrylic acid and pentaerythritol triallyl ether, neutralized with aqueous NaOH, dried, powdered, and surface- crosslinked with ethylene glycol diglycidyl ether to give a water-absorbing polymer showing gel modulus 50,000 N/m² and artificial urine absorption 32 g/g under 20 g/cm² pressure.

IT 198488-74-3P, Polyethylene glycol monoether with methyl α -(hydroxymethyl)acrylate 318234-53-6P,

Polyethylene glycol ether with butanol and methyl
 α -(hydroxymethyl)acrylate 876596-54-2F, Polyethylene
 glycol monoether with N,N-dimethyl- α -
 (hydroxymethyl)acrylamide 876596-57-5F, Polyethylene
 glycol ether with butanol and
 N,N-dimethyl- α -(hydroxymethyl)acrylamide
 (water-absorbing acrylic polyoxyalkylenes with high gel
 modulus and water absorbents containing them for sanitary goods)

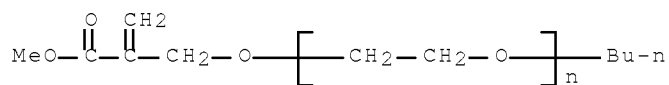
RN 198488-74-3 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-(methoxycarbonyl)-2-propenyl]-
 ω -hydroxy- (9CI) (CA INDEX NAME)



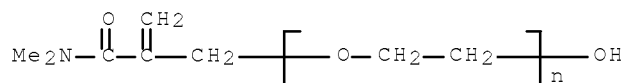
RN 318234-53-6 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -butyl- ω -[[2-(methoxycarbonyl)-
 2-propenyl]oxy]- (9CI) (CA INDEX NAME)



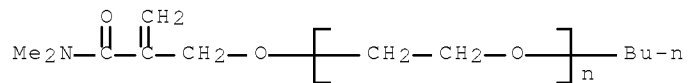
RN 876596-54-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-[(dimethylamino)carbonyl]-2-
 propenyl]- ω -hydroxy- (9CI) (CA INDEX NAME)



RN 876596-57-5 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -butyl- ω -[[2-
 [(dimethylamino)carbonyl]-2-propenyl]oxy]- (9CI) (CA INDEX NAME)



IT 876908-52-0F, Acrylic acid-ethylene glycol
 diglycidyl ether-pentaerythritol triallyl ether-polyethylene
 glycol monoether with methyl α -(hydroxymethyl) acrylate
 copolymer sodium salt 876908-56-4F, Acrylic acid-ethylene
 glycol diglycidyl ether-pentaerythritol triallyl

ether-polyethylene glycol monoether with
 N,N-dimethyl- α -(hydroxymethyl) acrylamide copolymer sodium salt
 876908-58-6P, Acrylic acid-ethylene glycol
 diglycidyl ether-pentaerythritol triallyl ether-polyethylene
 glycol ether with butanol and methyl α -(hydroxymethyl)
 acrylate copolymer sodium salt 876908-62-2P, Acrylic
 acid-ethylene glycol diglycidyl ether-pentaerythritol
 triallyl ether-polyethylene glycol ether with butanol and
 N,N-dimethyl- α -(hydroxymethyl)acrylamide copolymer sodium salt
 (water-absorbing acrylic polyoxyalkylenes with high gel
 modulus and water absorbents containing them for sanitary goods)

RN 876908-52-0 HCAPLUS

CN 2-Propenoic acid, polymer with
 2,2'-[1,2-ethanediylbis(oxymethylene)]bis[oxirane],
 α -[2-(methoxycarbonyl)-2-propenyl]- ω -hydroxypoly(oxy-1,2-
 ethanediyl) and 3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-
 propanol, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 876908-51-9

CMF (C14 H24 O4 . C8 H14 O4 . C3 H4 O2 . (C2 H4 O)n C5 H8 O3)x

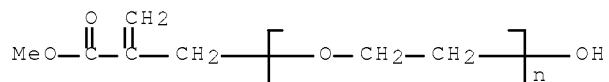
CCI PMS

CM 2

CRN 198488-74-3

CMF (C2 H4 O)n C5 H8 O3

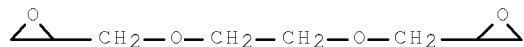
CCI PMS



CM 3

CRN 2224-15-9

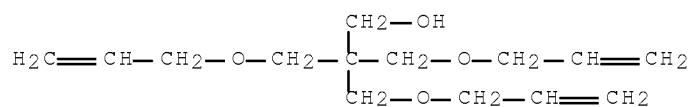
CMF C8 H14 O4



CM 4

CRN 1471-17-6

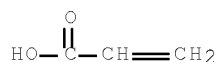
CMF C14 H24 O4



CM 5

CRN 79-10-7

CMF C3 H4 O2



RN 876908-56-4 HCAPLUS

CN 2-Propenoic acid, polymer with

 α -[2-[(dimethylamino)carbonyl]-2-propenyl]- ω -

hydroxypoly(oxy-1,2-ethanediyl),

2,2'-[1,2-ethanediylbis(oxymethylene)]bis[oxirane] and

3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-propanol, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 876908-55-3

CMF (C14 H24 O4 . C8 H14 O4 . C3 H4 O2 . (C2 H4 O)_n C6 H11 N O2)_x

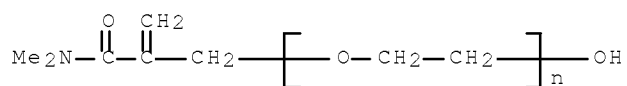
CCI PMS

CM 2

CRN 876596-54-2

CMF (C2 H4 O)_n C6 H11 N O2

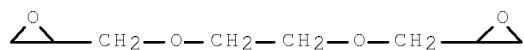
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CM 3

CRN 2224-15-9

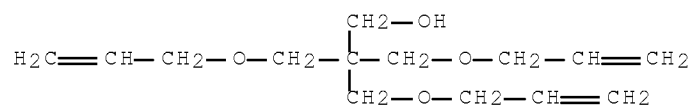
CMF C8 H14 O4



CM 4

CRN 1471-17-6

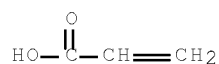
CMF C14 H24 O4



CM 5

CRN 79-10-7

CMF C3 H4 O2



RN 876908-58-6 HCAPLUS

CN 2-Propenoic acid, polymer with

α -butyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]poly(oxy-1,2-ethanediyl), 2,2'-[1,2-ethanediylbis(oxymethylene)]bis[oxirane] and 3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-propanol, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 876908-57-5

CMF (C14 H24 O4 . C8 H14 O4 . C3 H4 O2 . (C2 H4 O)_n C9 H16 O3)_x

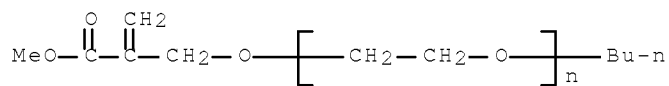
CCI PMS

CM 2

CRN 318234-53-6

CMF (C2 H4 O)_n C9 H16 O3

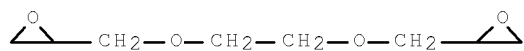
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CM 3

CRN 2224-15-9

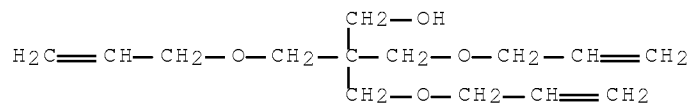
CMF C8 H14 O4



CM 4

CRN 1471-17-6

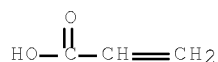
CMF C14 H24 O4



CM 5

CRN 79-10-7

CMF C3 H4 O2



RN 876908-62-2 HCAPLUS

CN 2-Propenoic acid, polymer with

α -butyl- ω -[[2-[(dimethylamino)carbonyl]-2-propenyl]oxy]poly(oxy-1,2-ethanediyl),
2,2'-[1,2-ethanediylbis(oxymethylene)]bis[oxirane] and
3-(2-propenyloxy)-2,2-bis[(2-propenyloxy)methyl]-1-propanol, sodium
salt (9CI) (CA INDEX NAME)

CM 1

CRN 876908-61-1

CMF (C14 H24 O4 . C8 H14 O4 . C3 H4 O2 . (C2 H4 O)_n C10 H19 N O2)_x

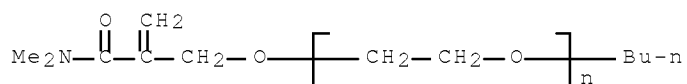
CCI PMS

CM 2

CRN 876596-57-5

CMF (C2 H4 O)_n C10 H19 N O2

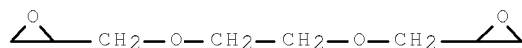
CCI PMS



CM 3

CRN 2224-15-9

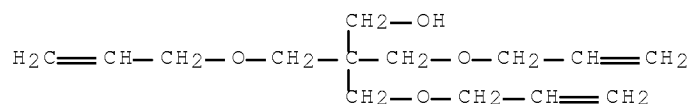
CMF C8 H14 O4



CM 4

CRN 1471-17-6

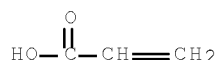
CMF C14 H24 O4



CM 5

CRN 79-10-7

CMF C3 H4 O2



- CC 38-3 (Plastics Fabrication and Uses)
Section cross-reference(s): 63
- ST gel modulus acrylic polyoxyalkylene water absorbent;
sanitary goods acrylic polyoxyalkylene water absorbent;
polyoxyethylene hydroxymethylacrylate monoether macromonomer acrylic
polyoxyalkylene
- IT Medical goods
(absorbents, sanitary goods; water-absorbing acrylic
polyoxyalkylenes with high gel modulus and water absorbents
containing them for sanitary goods)
- IT Polyoxyalkylenes, uses
(acrylic; water-absorbing acrylic polyoxyalkylenes with
high gel modulus and water absorbents containing them for sanitary
goods)
- IT Absorbents
(medical, sanitary goods; water-absorbing acrylic
polyoxyalkylenes with high gel modulus and water absorbents
containing them for sanitary goods)
- IT Polyoxyalkylenes, preparation
(vinyl-terminated; water-absorbing acrylic polyoxyalkylenes
with high gel modulus and water absorbents containing them for sanitary
goods)

- IT Macromonomers
(water-absorbing acrylic polyoxyalkylenes with high gel modulus and water absorbents containing them for sanitary goods)
- IT Absorbents
(water; water-absorbing acrylic polyoxyalkylenes with high gel modulus and water absorbents containing them for sanitary goods)
- IT 4224-69-5P, Methyl α -(bromomethyl)acrylate 15484-46-5P, Methyl α -(hydroxymethyl)acrylate 23873-54-3P, α -(Hydroxymethyl)acrylonitrile 183892-71-9P, Polyethylene glycol mono(2-carboxy-2-propenyl) ether sodium salt 198488-74-3P, Polyethylene glycol monoether with methyl α -(hydroxymethyl)acrylate 318234-53-6P, Polyethylene glycol ether with butanol and methyl α -(hydroxymethyl)acrylate 876596-52-0P, Polyethylene glycol ether with butanol and α -(hydroxymethyl)acrylonitrile 876596-54-2P, Polyethylene glycol monoether with N,N-dimethyl- α -(hydroxymethyl)acrylamide 876596-57-5P, Polyethylene glycol ether with butanol and N,N-dimethyl- α -(hydroxymethyl)acrylamide 876596-60-0P, Polyethylene glycol butyl 2-carboxy-2-propenyl ether sodium salt 876908-49-5P, Polyethylene glycol monoether with α -(hydroxymethyl)acrylonitrile 876908-50-8P, N,N-Dimethyl- α -(hydroxymethyl)acrylamide (water-absorbing acrylic polyoxyalkylenes with high gel modulus and water absorbents containing them for sanitary goods)
- IT 876908-52-0P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol monoether with methyl α -(hydroxymethyl) acrylate copolymer sodium salt 876908-54-2P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol monoether with α -(hydroxymethyl) acrylonitrile copolymer sodium salt 876908-56-4P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol monoether with N,N-dimethyl- α -(hydroxymethyl) acrylamide copolymer sodium salt 876908-58-6P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol ether with butanol and methyl α -(hydroxymethyl) acrylate copolymer sodium salt 876908-60-0P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol ether with butanol and α -(hydroxymethyl)acrylonitrile copolymer sodium salt 876908-62-2P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol ether with butanol and N,N-dimethyl- α -(hydroxymethyl)acrylamide copolymer sodium salt 876908-64-4P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol mono(2-carboxy-2-propenyl) ether sodium salt copolymer sodium salt 876908-66-6P, Acrylic acid-ethylene glycol diglycidyl ether-pentaerythritol triallyl ether-polyethylene glycol butyl 2-carboxy-2-propenyl ether sodium salt copolymer sodium salt (water-absorbing acrylic polyoxyalkylenes with high gel modulus and water absorbents containing them for sanitary goods)
- IT 50-00-0, Formaldehyde, reactions 96-33-3, Methyl acrylate

107-13-1, Acrylonitrile, reactions 2680-03-7, N,N-Dimethylacrylamide
(water-absorbing acrylic ~~polyoxyalkylenes~~ with high gel
modulus and water absorbents containing them for sanitary goods)

L50 ANSWER 7 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2005:120699 HCAPLUS Full-text

DOCUMENT NUMBER: 142:204753

TITLE: Pharmaceutical compositions of adsorbates of
amorphous drugs and lipophilic microphase-forming
materials

INVENTOR(S): Babcock, Walter Christian; Friesen, Dwayne Thomas;
Shanker, Ravi Mysore; Smithey, Daniel Tod

PATENT ASSIGNEE(S): Pfizer Products Inc., USA

SOURCE: PCT Int. Appl., 72 pp.

CODEN: PIXXD2

DOCUMENT TYPE: Patent

LANGUAGE: English

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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WO 2005011635	A2	20050210	WO 2004-IB2498	20040723
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WO 2005011635	A3	20050317		
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	CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI,			
	GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP,			
	KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW,			
	MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD,			
	SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ,			
	VC, VN, YU, ZA, ZM, ZW			
RW:	BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW,			
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	GW, ML, MR, NE, SN, TD, TG			
CA 2532931	A1	20050210	CA 2004-2532931	20040723
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EP 1653927	A2	20060510	EP 2004-744149	20040723
			<--	
R:	AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,			
	PT, IE, SI, FI, RO, CY, TR, BG, CZ, EE, HU, PL, SK			
BR 2004013277	A	20061010	BR 2004-13277	20040723
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JP 2007501218	T	20070125	JP 2006-522429	20040723
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US 20050031693	A1	20050210	US 2004-910448	20040803
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MX 2006001417	A	20060515	MX 2006-1417	20060203
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PRIORITY APPLN. INFO.:			US 2003-492410P	P 20030804
			<--	
			WO 2004-IB2498	W 20040723
			<--	

ASSIGNMENT HISTORY FOR US PATENT AVAILABLE IN LSUS DISPLAY FORMAT

AB A pharmaceutical composition comprises a solid adsorbate comprising a drug adsorbed onto a substrate and a lipophilic microphase-forming material. The solid adsorbate may also be co-administered with a lipophilic microphase-forming material to an in vivo use environment. The compns. of the present

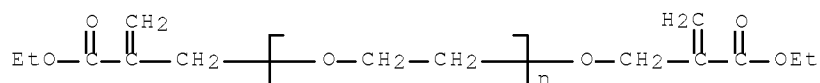
invention enhance the concentration of drug in a use environment. A drug/substrate adsorbate containing 50% [2R,4S] 4-[(3,5-bis-trifluoromethyl-benzyl)-methoxycarbonyl-amino]-2-ethyl-6- trifluoromethyl-3,4-dihydro-2H-quinoline-1-carboxylic acid Et ester and 50% CAB-O-SIL M-5P was prepared. The maximum concentration of drug in solution during the first 90 min MDC90 and AUC90 was 17.0 µg/mL and 840 min*µg/mL.

IT 333305-83-2

(pharmaceutical compns. of adsorbates of amorphous drugs and lipophilic microphase-forming materials)

RN 333305-83-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α-(3-ethoxy-2-methylene-3-oxopropyl)-ω-(3-ethoxy-2-methylene-3-oxopropoxy)- (9CI) (CA INDEX NAME)



IC ICM A61K0009-16

CC 63-6 (Pharmaceuticals)

IT 56-81-5D, Glycerol, fatty acid esters 57-55-6D, Propylene glycol, glycerides 7384-98-7, Propylene glycol dicaprylate 9002-89-5 9002-96-4, α-Tocopheryl polyethylene glycol succinate 9003-39-8, Polyvinylpyrrolidone 9004-38-0, Cellulose acetate phthalate 9004-65-3, Hydroxypropyl methyl cellulose 9005-64-5 9005-65-6 9050-31-1, Hydroxypropyl methyl cellulose phthalate 12441-09-7D, Sorbitan, polyglyceryl esters 27194-74-7, Propylene glycolmonolaurate 37205-99-5, Carboxymethylethyl cellulose 52907-01-4, Cellulose acetate trimellitate 57107-95-6 70535-77-2, Hydroxypropyl methyl cellulose acetate succinate 119574-41-3 333305-83-2 (pharmaceutical compns. of adsorbates of amorphous drugs and lipophilic microphase-forming materials)

RETABLER

Referenced Author (RAU)	Year (RPY)	VOL (RVL)	PG (RPG)	Referenced Work (RWK)	Referenced File
=====	=====	=====	=====	=====	=====
Anon				WO 0110410 A1	
Anon				WO 0147495 A1	HCAPLUS
Anon				WO 0168055 A1	HCAPLUS
Anon				WO 0211710 A2	HCAPLUS
Anon				WO 03000238 A1	HCAPLUS
Anon				WO 03063833 A1	HCAPLUS
Anon				US 20010053791 A1	HCAPLUS

OS.CITING REF COUNT: 3 THERE ARE 3 CAPLUS RECORDS THAT CITE THIS RECORD (3 CITINGS)

L50 ANSWER 8 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2004:963227 HCAPLUS Full-text

DOCUMENT NUMBER: 141:411779

TITLE: Inorganic powder-containing acrylic resin composition for calcination

INVENTOR(S): Maki, Keiji

PATENT ASSIGNEE(S): Nippon Shokubai Co., Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 17 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

June 18, 2010

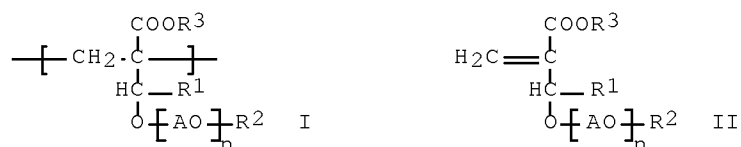
10/567,430

36

LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2004315720	A	20041111	JP 2003-113827	20030418
			<--	
JP 4185394	B2	20081126		
PRIORITY APPLN. INFO.:			JP 2003-113827	20030418
			<--	

GI



AB Title resin composition with super pyrolytic property is composed of acrylic resin (I) prepared from polymerization of (II), wherein R1 = H, C1-6 organic groups, R2 = H, C1-10 organic groups, R3 = C1-10 organic groups, A = C1-8 organic groups, n = 1-50, inorg. powders, and solvent. Thus, Me methacrylate and a monomer (II) with R1 = H, R2 = Me, R3 = Me, A = ethylene, and n = 3 were polymerized to receive an acrylic resin that can be mixed with silver powders and ethanol to receive a calcination resin composition

IT 791073-02-4P 791073-03-5P
 (inorg. powder-containing acrylic resin composition for calcination)

RN 791073-02-4 HCAPLUS

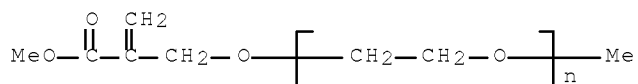
CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
 α -methyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]poly(oxy-
 1,2-ethanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 318234-49-0

CMF (C2 H4 O)n C6 H10 O3

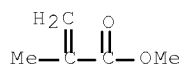
CCI PMS



CM 2

CRN 80-62-6

CMF C5 H8 O2



RN 791073-03-5 HCAPLUS

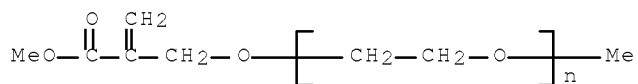
CN Poly(oxy-1,2-ethanediyl), α -methyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 318234-49-0

CMF (C2 H4 O)_n C6 H10 O3

CCI PMS



IC ICM C08L0033-14

ICS C08F0020-26; C08F0299-02; C08K0003-00; C08K0005-00;
G02F0001-1343; H05K0003-12

CC 37-6 (Plastics Manufacture and Processing)

ST silver powder polyoxyalkylene acrylic resin compn ethanol
calcination

IT Polyoxyalkylenes, preparation

(acrylic; inorg. powder-containing acrylic resin composition for
calcination)

IT 112419-44-0P 791073-02-4P 791073-03-5P

(inorg. powder-containing acrylic resin composition for calcination)

L50 ANSWER 9 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2003:734646 HCAPLUS Full-text

DOCUMENT NUMBER: 139:247031

TITLE: Ink jet compositions for ink jet printing

INVENTOR(S): Vanmaele, Luc; Loccufier, Johan

PATENT ASSIGNEE(S): Agfa-Gevaert, Belg.

SOURCE: Eur. Pat. Appl., 30 pp.

CODEN: EPXXDW

DOCUMENT TYPE: Patent

LANGUAGE: English

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
-----	----	-----	-----	-----
EP 1344805	A1	20030917	EP 2003-100338	20030214
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EP 1344805	B1	20051221		
R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,				
PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, SK				
US 20050277708	A1	20051215	US 2003-368324	20030218
			<--	
JP 2004027190	A	20040129	JP 2003-67791	20030313
			<--	
PRIORITY APPLN. INFO.:			EP 2002-100261	A 20020315

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ASSIGNMENT HISTORY FOR US PATENT AVAILABLE IN LSUS DISPLAY FORMAT

AB Radiation-curable ink compns. contain radiation-curable monomers $R_1XCOC(:CH_2)CR_2R_3Y$, where $R_1 = H$, a substituted or unsubstituted group selected from alkyl, alkenyl, alkynyl, aryl, aralkyl, cycloalkyl, heterocyclic group; $X = O, S, NR_4$; $Y = \text{halogen, a nitrile, OH, thiol, amino, a quaternary ammonium group, a quaternary phosphonium group, a } O:CR_5 \text{ group, a substituted or unsubstituted heterocyclic group, a functional group attached to } CR_2R_3 \text{ through a heteroatom in any oxidation state; } R_2 \text{ and } R_3 = H, R_1 \text{ and including a substituted or unsubstituted ether group, a substituted or unsubstituted thio ether group, a substituted or unsubstituted amine group, a substituted or unsubstituted acyl group, a substituted or unsubstituted sulfonyl group, a substituted or unsubstituted phosphonyl, a substituted or unsubstituted acyloxy group, or } R_2 \text{ and } R_3 \text{ form a ring or one of the substituents } R_2 \text{ or } R_3 \text{ forms a ring system with } Y; R_4 = H, R_1 \text{ or } R_1 \text{ and } R_4 \text{ form a ring; } R_5 = H, OH, R_1, \text{ a substituted or unsubstituted alkoxy group, a substituted or unsubstituted thioalkoxy group, a substituted or unsubstituted amino group, or } O A^+, \text{ where } A^+ \text{ represents any organic or inorg. counterion. Thus, 76.8 g (0.6 mol) tert-Bu acrylate was dissolved in 60 mL THF, 71.3 mL 35\% HCOH solution and 50 mL H₂O were stirred for 10 days at room temperature in the presence of 13.5 g (0.12 mol) DABCO to give hydroxymethylated tert-Bu acrylate.$

IT 600164-64-5P 600164-69-0P

(ink jet printing of radiation-cured inks of)

RN 600164-64-5 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-(ethoxycarbonyl)-2-propenyl]- ω -methoxy-, polymer with Craynor CN 501 and Ebecryl P 115 (9CI)
(CA INDEX NAME)

CM 1

CRN 265309-33-9

CMF Unspecified

CCI PMS, MAN

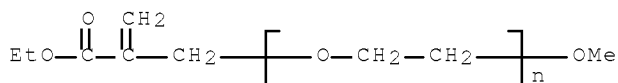
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CM 2

CRN 204327-57-1

CMF (C2 H4 O)_n C7 H12 O3

CCI PMS



CM 3

CRN 167748-98-3

CMF Unspecified

CCI MAN

*** STRUCTURE DIAGRAM IS NOT AVAILABLE ***

RN 600164-69-0 HCAPLUS

CN 2-Propenoic acid, oxybis(methyl-2,1-ethanediyl) ester, polymer with

Craynor CN 501 and α -[2-(ethoxycarbonyl)-2-propenyl]- ω -methoxypoly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 265309-33-9

CMF Unspecified

CCI PMS, MAN

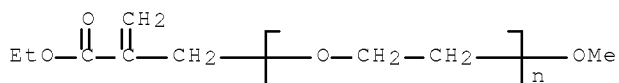
*** STRUCTURE DIAGRAM IS NOT AVAILABLE ***

CM 2

CRN 204327-57-1

CMF (C2 H4 O)_n C7 H12 O3

CCI PMS

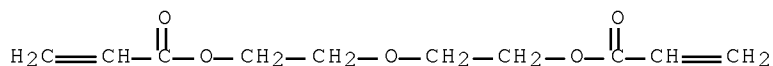


CM 3

CRN 57472-68-1

CMF C12 H18 O5

CCI IDS



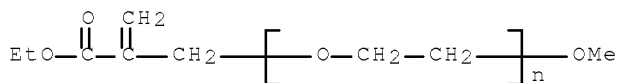
2 (D1-Me)

IT 204327-57-1P

(reactive diluent; reactive diluent for ink jet compns.)

RN 204327-57-1 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-(ethoxycarbonyl)-2-propenyl]- ω -methoxy- (9CI) (CA INDEX NAME)



IC C09D0011-10; C09D0011-00

CC 42-12 (Coatings, Inks, and Related Products)

ST radiation curable diluent hydroxymethylated alkyl acrylate
ink jet printing

IT Inks

(radiation-curable; reactive diluent for ink jet compns.)

June 18, 2010

10/567,430

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IT 600164-60-1P 600164-61-2P 600164-62-3P ~~600164-64-5P~~
 600164-66-7P 600164-67-8P 600164-68-9P ~~600164-69-0P~~
 (ink jet printing of radiation-cured inks of)
 IT 111-92-2, Dibutylamine 122-52-1, Triethyl phosphite 9004-74-4,
 Monomethoxy polyethylene glycol
 (reaction with Et bromomethacrylate; reactive diluent for ink jet
 compns.)
 IT 10029-04-6P 61203-64-3P 121065-74-5P ~~204327-57-1P~~
 600164-59-8P
 (reactive diluent; reactive diluent for ink jet compns.)

RETABLE

Referenced Author (RAU)	Year (RPY)	VOL (RVL)	PG (RPG)	Referenced Work (RWK)	Referenced File
Canon Kk	1999			EP 0953613 A	HCAPLUS
Johnson, S	1999			WO 9929787 A	HCAPLUS
Seiko Epson Corp	2000			EP 1036831 A	HCAPLUS
Vanmaele, L	2001			US 6300388 B1	HCAPLUS

OS.CITING REF COUNT: 7 THERE ARE 7 CAPLUS RECORDS THAT CITE THIS
 RECORD (7 CITINGS)

L50 ANSWER 10 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN
 ACCESSION NUMBER: 2003:202933 HCAPLUS Full-text
 DOCUMENT NUMBER: 138:226803
 TITLE: Polymers containing acrylamide derivative monomer
 for ocular lenses
 INVENTOR(S): Nakamura, Masataka; Fujisawa, Kazuhiko; Shimoyama,
 Naoki; Yokota, Mitsuru
 PATENT ASSIGNEE(S): Toray Industries, Inc., Japan
 SOURCE: PCT Int. Appl., 33 pp.
 CODEN: PIXXD2
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 2003021337	A1	20030313	WO 2001-JP7390	20010828
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W: AU, US				
RW: AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, TR				
AU 2001280213	A1	20030318	AU 2001-280213	20010828
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AU 2001280213	B2	20070426		
EP 1445641	A1	20040811	EP 2001-958580	20010828
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EP 1445641	B1	20071003		
R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, FI, CY, TR				
US 20040201820	A1	20041014	US 2004-488089	20040225
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US 7329694	B2	20080212		
PRIORITY APPLN. INFO.:			WO 2001-JP7390	W 20010828
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ASSIGNMENT HISTORY FOR US PATENT AVAILABLE IN LSUS DISPLAY FORMAT

AB This invention relates to an ocular lens which has a high tensile elongation
 (i.e., is less apt to break). The ocular lens is characterized by containing
 units derived from a monomer represented by the following general formula

CH₂:CR₁CONH(L₁)kL₂OR₂, where R₁ represents hydrogen or methyl; R₂ represents a group selected among C₁-8 alkyl, C₇-12 aralkyl, and C₆-10 aryl; k is an integer of 0 to 2; L₁ represents a substituent selected among ethylene, 1,2-propylene, 1,3-propylene, and 1,4-butylene; and L₂ represents a substituent selected among methylene, ethylene, 1,2-propylene, 1,3-propylene, and 1,4-butylene. Siloxanyl monomers are also contained. A mixture of N,N-dimethylacrylamide, N-(2-methoxyethyl)acrylamide (preparation given), polyethylene glycol dimethacrylate, MeOCOC(:CH₂)CH₂OCH₂CH₂O(CH₂)₃Si(OSiMe₃)₃ (preparation given), diethylene glycol di-Me ether, and Darocur 1173 was irradiated with light in a mold. The resulting contact lens had tensile elongation 480 %.

IT 501015-10-7P 501015-11-8P 501015-12-9P

(preparation of polymers containing acrylamide derivative and siloxanyl monomers

for ocular lenses)

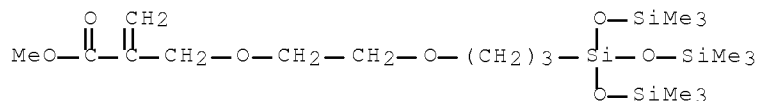
RN 501015-10-7 HCAPLUS

CN 2-Propenoic acid, 2-[[2-[3-[3,3,3-trimethyl-1,1-bis[(trimethylsilyl)oxy]-1-disiloxanyl]propoxy]ethoxy]methyl]-, methyl ester, polymer with N,N-dimethyl-2-propenamide, N-(2-methoxyethyl)-2-propenamide, α-(2-methyl-1-oxo-2-propen-1-yl)-ω-[(2-methyl-1-oxo-2-propen-1-yl)oxy]poly(oxy-1,2-ethanediyl) and 1,1'-oxybis[2-methoxyethane] (CA INDEX NAME)

CM 1

CRN 345636-02-4

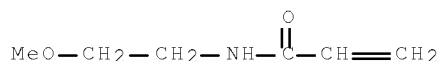
CMF C19 H44 O7 Si4



CM 2

CRN 81666-02-6

CMF C6 H11 N O2

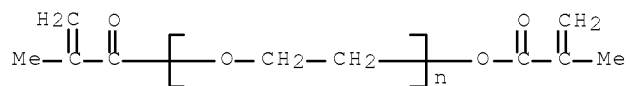


CM 3

CRN 25852-47-5

CMF (C2 H4 O)_n C8 H10 O3

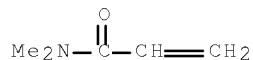
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CM 4

CRN 2680-03-7

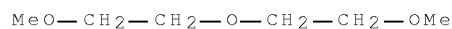
CMF C5 H9 N O



CM 5

CRN 111-96-6

CMF C6 H14 O3



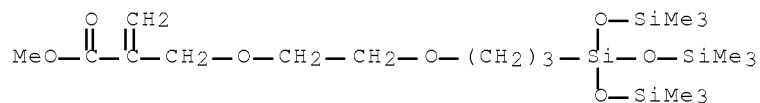
RN 501015-11-8 HCAPLUS

CN 2-Propenoic acid, 2-[[2-[3-[3,3,3-trimethyl-1,1-bis[(trimethylsilyl)oxy]-1-disiloxanyl]propoxy]ethoxy]methyl]-, methyl ester, polymer with N,N-dimethyl-2-propenamide, N-(3-methoxypropyl)-2-propenamide, α -(2-methyl-1-oxo-2-propen-1-yl)- ω -[(2-methyl-1-oxo-2-propen-1-yl)oxy]poly(oxy-1,2-ethanediyl) and 1,1'-oxybis[2-methoxyethane] (CA INDEX NAME)

CM 1

CRN 345636-02-4

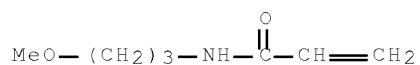
CMF C19 H44 O7 Si4



CM 2

CRN 107374-86-7

CMF C7 H13 N O2

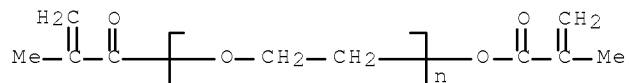


CM 3

CRN 25852-47-5

CMF (C2 H4 O)_n C8 H10 O3

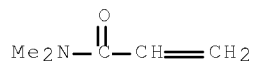
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CM 4

CRN 2680-03-7

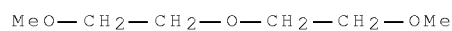
CMF C5 H9 N O



CM 5

CRN 111-96-6

CMF C6 H14 O3



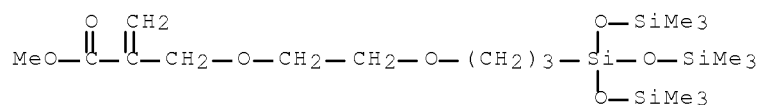
RN 501015-12-9 HCAPLUS

CN 2-Propenoic acid, 2-[[2-[3-[3,3,3-trimethyl-1,1-bis[(trimethylsilyl)oxy]-1-disiloxanyl]propoxy]ethoxy]methyl]-, methyl ester, polymer with N-(methoxymethyl)-2-propenamide, α-(2-methyl-1-oxo-2-propen-1-yl)-ω-[(2-methyl-1-oxo-2-propen-1-yl)oxy]poly(oxy-1,2-ethanediyl) and 1,1'-oxybis[2-methoxyethane] (CA INDEX NAME)

CM 1

CRN 345636-02-4

CMF C19 H44 O7 Si4

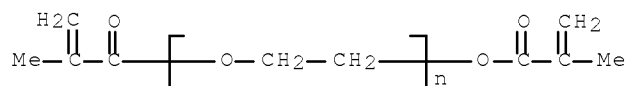


CM 2

CRN 25852-47-5

CMF (C2 H4 O)_n C8 H10 O3

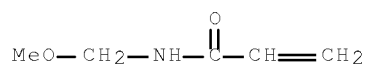
CCI PMS



CM 3

CRN 3644-11-9

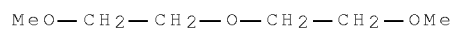
CMF C5 H9 N O2



CM 4

CRN 111-96-6

CMF C6 H14 O3



IC ICM G02C0007-04

ICS C08F0020-58; A61F0002-16

CC 63-7 (Pharmaceuticals)

Section cross-reference(s): 38

IT 501015-10-7P 501015-11-8P 501015-12-9P

501015-13-0P 501015-14-1P

(preparation of polymers containing acrylamide derivative and siloxanyl monomers

for ocular lenses)

IT 75-77-4, Chlorotrimethylsilane, reactions 109-85-3,
2-Methoxyethylamine 111-45-5, Ethylene glycol monoallyl
ether 814-68-6, Acryloyl chloride 929-06-6,
2-(2-Aminoethoxy)ethanol 1825-61-2, Methoxytrimethylsilane
5332-73-0, 3-Methoxypropylamine 7789-60-8, Phosphorus tribromide
10025-78-2, Trichlorosilane 10029-04-6 15484-46-5

(preparation of polymers containing acrylamide derivative and siloxanyl monomers

for ocular lenses)

RETABLE

Referenced Author (RAU)	Year (RPY)	VOL (RVL)	PG (RPG)	Referenced Work (RWK)	Referenced File
Mitsui Toatsu Chemicals	1985			JP 60-190424 A	HCAPLUS
Permeable Technologies	1992			JP 06-503103 A	
Permeable Technologies	1992			EP 552306 A1	HCAPLUS
Permeable Technologies	1992			AU 9189550 A	HCAPLUS
Permeable Technologies	1992			WO 9207013 A1	HCAPLUS
Smith & Nephew Research	1977			IT 1036430 B	
Smith & Nephew Research	1977			CA 1037196 A	HCAPLUS
Smith & Nephew Research	1977			DD 123396 A	HCAPLUS
Smith & Nephew Research	1977			GB 1494641 A	HCAPLUS
Smith & Nephew Research	1977			FR 2277110 A	HCAPLUS
Smith & Nephew Research	1977			DE 2529639 A	HCAPLUS
Smith & Nephew Research	1977			DE 2529639 C	HCAPLUS
Smith & Nephew Research	1977			US 4036814 A	HCAPLUS
Smith & Nephew Research	1977			IL 47636 A	
Smith & Nephew Research	1977			JP 51-30750 A	HCAPLUS
Smith & Nephew Research	1977			CH 603708 A	HCAPLUS
Smith & Nephew Research	1977			FI 7501961 A	HCAPLUS
Smith & Nephew Research	1977			NO 7502351 A	HCAPLUS
Smith & Nephew Research	1977			DK 7503006 A	HCAPLUS
Smith & Nephew Research	1977			ZA 7504036 A	HCAPLUS
Smith & Nephew Research	1977			BR 7504329 A	
Smith & Nephew Research	1977			CS 7504749 A	
Smith & Nephew Research	1977			AT 7505036 A	
Smith & Nephew Research	1977			SE 7507693 A	HCAPLUS
Smith & Nephew Research	1977			NL 7507914 A	HCAPLUS
Smith & Nephew Research	1977			BE 831047 A	HCAPLUS
Toray Industries Inc	2001			JP 2001220394 A	HCAPLUS
Toray Industries Inc	2001			JP 2001245910 A	HCAPLUS
Toray Industries Inc	2001			JP 2001530 A	
Toray Industries Ltd	1982			CA 1136306 A	HCAPLUS
Toray Industries Ltd	1982			CA 1149563 A	
Toray Industries Ltd	1982			GB 2006091 A	HCAPLUS
Toray Industries Ltd	1982			FR 2402525 A	HCAPLUS
Toray Industries Ltd	1982			DE 2839249 A	HCAPLUS
Toray Industries Ltd	1982			US 4347198 A	
Toray Industries Ltd	1982			US 4699934 A	HCAPLUS
Toray Industries Ltd	1982			JP 63-234001 A	

OS.CITING REF COUNT: 1 THERE ARE 1 CAPLUS RECORDS THAT CITE THIS RECORD (1 CITINGS)

L50 ANSWER 11 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 2001:666553 HCAPLUS Full-text

DOCUMENT NUMBER: 135:231737

TITLE: Ocular lenses with increased tensile elongation

INVENTOR(S): Nakamura, Masataka; Fujisawa, Kazuhiko; Shimoyama, Naoki; Yokota, Mitsuru

PATENT ASSIGNEE(S): Toray Industries, Inc., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 13 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
-----	----	-----	-----	-----
JP 2001245910	A	20010911	JP 2000-58421	20000303
			<--	
JP 4273612	B2	20090603		
PRIORITY APPLN. INFO.:			JP 2000-58421	20000303
			<--	

AB The ocular lenses, especially contact lenses, contain CH₂:CR₁CONH(L₁O)_kL₂OR₂ [R₁ = H, Me; R₂ = C₁-8 alkyl, C₇-12 aralkyl, C₆-10 aryl; k = 0-2; L₁ = CH₂CH₂, 1,2-propylene, (CH₂)₃, (CH₂)₄; L₂ = CH₂, CH₂CH₂, 1,2-propylene, (CH₂)₃, (CH₂)₄] as a polymerizing monomer. Siloxanyl monomers may be contained. A mixture of N,N-dimethylacrylamide, N-(2-methoxyethyl)acrylamide (preparation given), polyethylene glycol dimethacrylate, MeOCOC(:CH₂)CH₂OCH₂CH₂O(CH₂)₃Si(OSiMe₃)₃ (preparation given), diethylene glycol di-Me ether, and Darocur 1173 was irradiated with light in a mold. The resulting contact lens had tensile elongation 480%.

IT 359630-87-8P 359630-88-9P 359630-89-0P
(ocular lenses with increased tensile elongation from polymers containing N-[alkoxyalkyl(oxyalkyl)]acrylamides)

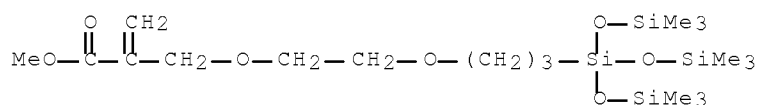
RN 359630-87-8 HCAPLUS

CN 2-Propenoic acid, 2-[[2-[3-[3,3,3-trimethyl-1,1-bis[(trimethylsilyl)oxy]-1-disiloxanyl]propoxy]ethoxy]methyl]-, methyl ester, polymer with N,N-dimethyl-2-propenamide, N-(2-methoxyethyl)-2-propenamide and α-(2-methyl-1-oxo-2-propen-1-yl)-ω-[(2-methyl-1-oxo-2-propen-1-yl)oxy]poly(oxy-1,2-ethanediyl) (CA INDEX NAME)

CM 1

CRN 345636-02-4

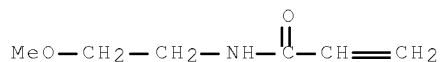
CMF C19 H44 O7 Si4



CM 2

CRN 81666-02-6

CMF C6 H11 N O2

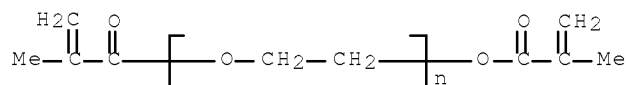


CM 3

CRN 25852-47-5

CMF (C2 H4 O)_n C8 H10 O3

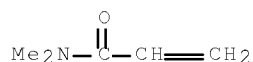
CCI PMS



CM 4

CRN 2680-03-7

CMF C5 H9 N O



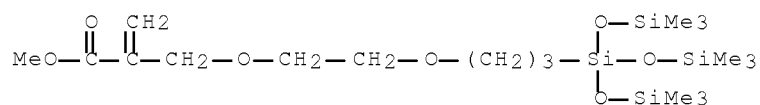
RN 359630-88-9 HCAPLUS

CN 2-Propenoic acid, 2-[[2-[3-[3,3,3-trimethyl-1,1-bis[(trimethylsilyl)oxy]-1-disiloxanyl]propoxy]ethoxy)methyl]-, methyl ester, polymer with N,N-dimethyl-2-propenamide, N-(3-methoxypropyl)-2-propenamide and α -(2-methyl-1-oxo-2-propen-1-yl)- ω -(2-methyl-1-oxo-2-propen-1-yl)oxy]poly(oxy-1,2-ethanediyl) (CA INDEX NAME)

CM 1

CRN 345636-02-4

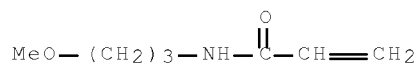
CMF C19 H44 O7 Si4



CM 2

CRN 107374-86-7

CMF C7 H13 N O2

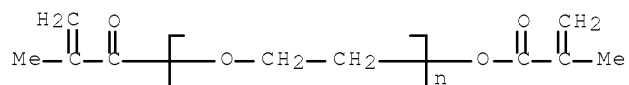


CM 3

CRN 25852-47-5

CMF (C2 H4 O)_n C8 H10 O3

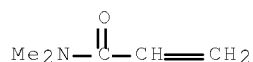
CCI PMS



CM 4

CRN 2680-03-7

CMF C5 H9 N O



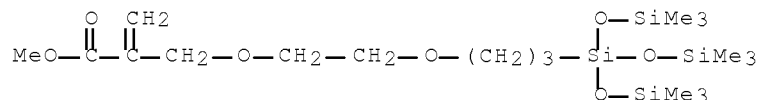
RN 359630-89-0 HCAPLUS

CN 2-Propenoic acid, 2-[[2-[3-[3,3,3-trimethyl-1,1-bis[(trimethylsilyl)oxy]-1-disiloxanyl]propoxy]ethoxy]methyl]-, methyl ester, polymer with N-(methoxymethyl)-2-propenamide and α -(2-methyl-1-oxo-2-propen-1-yl)- ω -(2-methyl-1-oxo-2-propen-1-yl)oxy]poly(oxy-1,2-ethanediyl) (CA INDEX NAME)

CM 1

CRN 345636-02-4

CMF C19 H44 O7 Si4

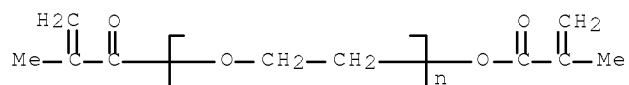


CM 2

CRN 25852-47-5

CMF (C2 H4 O)_n C8 H10 O3

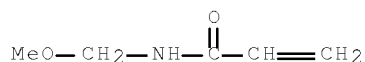
CCI PMS



CM 3

CRN 3644-11-9

CMF C5 H9 N O2



IC ICM A61F0002-16
ICS A61L0027-00; G02B0001-04; G02C0007-04; C08J0005-00; C08L0033-26
CC 63-7 (Pharmaceuticals)
Section cross-reference(s): 38
IT ~~359630-87-8P~~ ~~359630-88-9P~~ ~~359630-89-0P~~
359630-90-3P 359630-91-4P
(ocular lenses with increased tensile elongation from polymers
containing N-[alkoxyalkyl(oxyalkyl)]acrylamides)
IT 109-85-3, 2-Methoxyethylamine 111-45-5, Ethylene glycol
monoallyl ether 814-68-6, Acryloyl chloride 929-06-6,
2-(2-Aminoethoxy)ethanol 1825-61-2, Methoxytrimethylsilane
5332-73-0, 3-Methoxypropylamine 10029-04-6 15484-46-5
(ocular lenses with increased tensile elongation from polymers
containing N-[alkoxyalkyl(oxyalkyl)]acrylamides)
OS.CITING REF COUNT: 1 THERE ARE 1 CAPLUS RECORDS THAT CITE THIS
RECORD (1 CITINGS)

L50 ANSWER 12 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN
ACCESSION NUMBER: 2001:56894 HCAPLUS Full-text
DOCUMENT NUMBER: 134:86986
TITLE: Water-soluble vinyl alcohol polymers with
~~polyoxyalkylene~~ side chains
INVENTOR(S): Somemiya, Toshitaka; Fujiwara, Naoki
PATENT ASSIGNEE(S): Kuraray Co., Ltd., Japan
SOURCE: Jpn. Kokai Tokkyo Koho, 9 pp.
CODEN: JKXXAF
DOCUMENT TYPE: Patent
LANGUAGE: Japanese
FAMILY ACC. NUM. COUNT: 1
PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
-----	---	-----	-----	-----
JP 2001019720	A	20010123	JP 1999-195180	19990709
			<--	
JP 4128310	B2	20080730		
PRIORITY APPLN. INFO.:			JP 1999-195180	19990709
			<--	

AB The polymers, useful for films, coatings, and adhesives, have 0.01-15 mol% CH₂C(CO₂X)[(OR₁)_nOR₂] units [R₁= C₂-4 (un)substituted alkylene; R₂ = H, organic group; X = H, alkali metal; n = 1-100]. Thus, 2000 g vinyl acetate and 500 g Me 2-[(ω-hydroxypolyalkyleneglycoxy)methyl]acrylate were polymerized and saponified with NaOH to give a polymer with saponification degree 98.5% and good solubility in H₂O at 20°.

IT ~~318234-50-3DP~~, saponified ~~318234-52-5DP~~, saponified
~~318234-54-7DP~~, saponified ~~318245-85-1DP~~, saponified
(~~polyoxyalkylene~~-grafted poly(vinyl alcs.) with good
water solubility)
RN 318234-50-3 HCAPLUS
CN Acetic acid ethenyl ester, polymer with
α-methyl-ω-[[2-(methoxycarbonyl)-2-propenyl]oxy]poly(oxy-

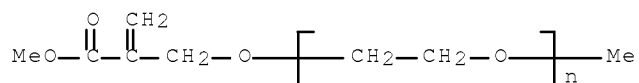
1,2-ethanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 318234-49-0

CMF (C2 H4 O)_n C6 H10 O3

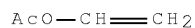
CCI PMS



CM 2

CRN 108-05-4

CMF C4 H6 O2



RN 318234-52-5 HCAPLUS

CN Acetic acid ethenyl ester, polymer with

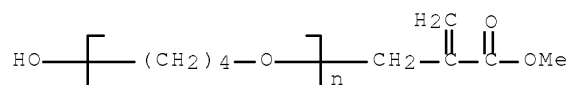
α -[2-(methoxycarbonyl)-2-propenyl]- ω -hydroxypoly(oxy-1,4-butanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 318234-51-4

CMF (C4 H8 O)_n C5 H8 O3

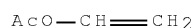
CCI PMS



CM 2

CRN 108-05-4

CMF C4 H6 O2



RN 318234-54-7 HCAPLUS

CN Acetic acid ethenyl ester, polymer with

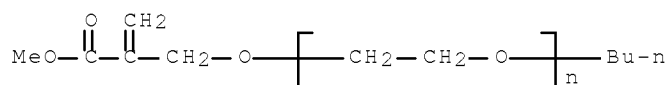
α -butyl- ω -[[2-(methoxycarbonyl)-2-propenyl]oxy]poly(oxy-1,2-ethanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 318234-53-6

CMF (C2 H4 O)_n C9 H16 O3

CCI PMS



CM 2

CRN 108-05-4

CMF C4 H6 O2



RN 318245-85-1 HCAPLUS

CN Acetic acid ethenyl ester, polymer with

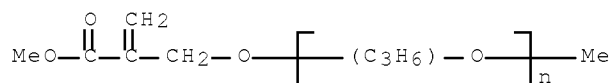
α -methyl- ω -(3-methoxy-2-methylene-3-oxopropoxy)poly[oxy(methyl-1,2-ethanediyl)], graft (9CI) (CA INDEX NAME)

CM 1

CRN 318245-84-0

CMF (C3 H6 O)_n C6 H10 O3

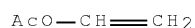
CCI IDS, PMS



CM 2

CRN 108-05-4

CMF C4 H6 O2



IC ICM C08F0218-04

ICS C08F0008-12; C08F0290-12; C08F0218-04; C08F0220-06

CC 37-3 (Plastics Manufacture and Processing)

ST polyoxyalkylene graft polyvinyl alc water soly;

polyoxyethylene hydroxymethylacrylate ether vinyl acetate copolymer
IT Polyoxyalkylenes, preparation
(polyvinyl alc., graft; polyoxyalkylene-grafted
poly(vinyl alcs.) with good water solubility)
IT Polymers, preparation
(water-soluble; polyoxyalkylene-grafted poly(vinyl alcs.)
with good water solubility)
IT 172017-08-2DP, Ethylene oxide-vinyl acetate graft copolymer butyl
ether, saponified 172017-09-3DP, Ethylene oxide-vinyl acetate graft
copolymer methyl ether, saponified 318234-50-3DP, saponified
318234-52-5DP, saponified 318234-54-7DP, saponified
318234-89-8DP, Ethylene oxide-propylene oxide block copolymer
monoether with methyl (2-hydroxymethyl)acrylate, polymer with vinyl
acetate, graft, saponified 318234-91-2DP, Ethylene oxide-propylene
oxide copolymer monoether with methyl (2-hydroxymethyl)acrylate,
polymer with vinyl acetate, graft, saponified 318234-93-4DP, Ethylene
oxide-propylene oxide block copolymer monomethyl ether, ether with
(2-hydroxymethyl)acrylate, polymer with vinyl acetate, graft, saponified
318234-94-5DP, Propylene oxide-vinyl acetate graft copolymer methyl
ether, saponified 318245-85-1DP, saponified
(polyoxyalkylene-grafted poly(vinyl alcs.) with good
water solubility)
OS.CITING REF COUNT: 2 THERE ARE 2 CAPLUS RECORDS THAT CITE THIS
RECORD (2 CITINGS)

L50 ANSWER 13 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN
ACCESSION NUMBER: 1998:555739 HCAPLUS Full-text
DOCUMENT NUMBER: 129:217409
ORIGINAL REFERENCE NO.: 129:44191a,44194a
TITLE: Odorless hardenable polymer compositions
containing acrylate monomers
INVENTOR(S): Yamazaki, Isahide; Nakakawa, Koichi; Maki, Keishi
PATENT ASSIGNEE(S): Nippon Shokubai Kagaku Kogyo Co., Ltd., Japan
SOURCE: Jpn. Kokai Tokkyo Koho, 17 pp.
CODEN: JKXXAF
DOCUMENT TYPE: Patent
LANGUAGE: Japanese
FAMILY ACC. NUM. COUNT: 1
PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
-----	----	-----	-----	-----
JP 10226716	A	19980825	JP 1997-30966	19970214
			<--	
PRIORITY APPLN. INFO.:			JP 1997-30966	19970214
			<--	

AB Title compns. comprise hardenable polymers and polymerizable unsatd. monomers
CH₂:C(CO₂R₁)(CHR₂OCHR₃OR₄) [R₁, R₄ = C₁-18 alkyl, C₃-8 cycloalkyl, C₆-18 aryl,
(CHR₅CH₂O)mR₆; R₂-R₃ = H, C₁-6 alkyl, C₃-8 cycloalkyl, C₆-18 aryl; R₅ = H, Me;
R₆ = H, C₁-6 alkyl, C₃-8 cycloalkyl, C₆-18 aryl; m = 1-4]. Thus, isophthalic
acid 415, propylene glycol 600, and maleic anhydride 245 parts were treated to
obtain an unsatd. polyester, which was mixed with 1026 parts Et α-
ethoxymethoxymethylacrylate and 0.20 part hydroquinone to obtain an odorless
composition giving a molding with high mech. strength and a coating with good
adhesion to ABS, PVC, and PC.

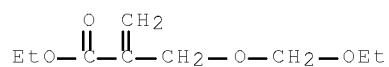
IT 212191-70-3P
(odorless hardenable polymer compns. containing acrylate monomers for
moldings with good mech. strength)
RN 212191-70-3 HCAPLUS
CN 2-Propenoic acid, 2-[(ethoxymethoxy)methyl]-, ethyl ester, polymer

with 2,4-diisocyanato-1-methylbenzene, 2-hydroxypropyl
2-methyl-2-propenoate and α, α' -[(1-methylethylidene)di-4,1-
phenylene]bis[ω -hydroxypoly[oxy(methyl-1,2-ethanediyl)]] (9CI)
(CA INDEX NAME)

CM 1

CRN 188945-86-0

CMF C9 H16 O4

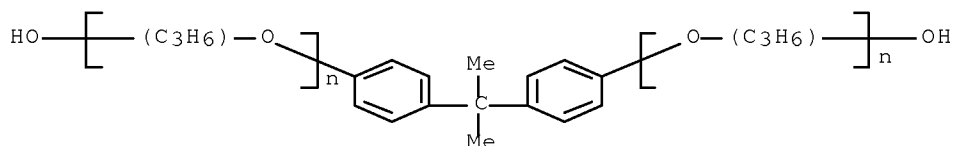


CM 2

CRN 37353-75-6

CMF (C3 H6 O)_n (C3 H6 O)_n C15 H16 O2

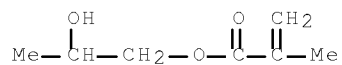
CCI IDS, PMS



CM 3

CRN 923-26-2

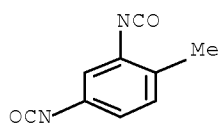
CMF C7 H12 O3



CM 4

CRN 584-84-9

CMF C9 H6 N2 O2



IC ICM C08F0290-00

ICS C07C0069-734; C07C0069-736; C08F0291-00; C08F0220-26
 CC 37-6 (Plastics Manufacture and Processing)
 Section cross-reference(s): 38
 IT 212191-69-0P ~~212191-70-3P~~ 212271-20-0P 212271-23-3P
 212271-24-4P
 (odorless hardenable polymer compns. containing acrylate monomers for moldings with good mech. strength)

L50 ANSWER 14 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN
 ACCESSION NUMBER: 1997:618705 HCAPLUS Full-text
 DOCUMENT NUMBER: 127:293762
 ORIGINAL REFERENCE NO.: 127:57431a
 TITLE: Purification of acrylate ester derivatives by removal of crosslinkable impurities
 INVENTOR(S): Nagano, Hideaki; Makino, Komei; Nakagawa, Koichi; Kita, Yuichi
 PATENT ASSIGNEE(S): Nippon Shokubai Kagaku Kogyo Co., Ltd., Japan
 SOURCE: Jpn. Kokai Tokkyo Koho, 11 pp.
 CODEN: JKXXAF
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

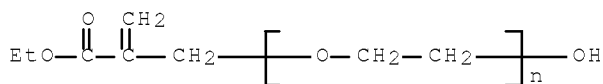
PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 09241215	A	19970916	JP 1996-46496	19960304
			<--	
PRIORITY APPLN. INFO.:			JP 1996-46496	19960304
			<--	

AB The derivs. H₂C:C(CO₂R₃)CHR₁₀[CH₂(CHR₂)_nO]_mH (R₁, R₂ = H, organic residues; R₃ = organic residues; m = 1-100; n = 1-3) are purified by washing with organic solvents having higher solubility to title impurities than to the derivs. Thus, reacting 130 g ethyl- α -hydroxymethyl acrylate with 462 g oxirane at 35-45° in PhMe in the presence of BF₃OEt₂ gave a crude acrylate ester (OH value 96.9 mg-KOH/g), which was washed with cyclohexane to give a pale-yellow liquid, which underwent polymerization in the presence of AIBN without gelation.

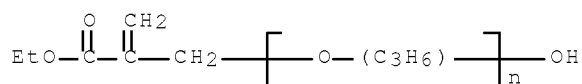
IT 183892-60-6P 184014-31-1P
 (purification of acrylate ester derivs. by solvent extraction)

RN 183892-60-6 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -[2-(ethoxycarbonyl)-2-propenyl]- ω -hydroxy- (9CI) (CA INDEX NAME)



RN 184014-31-1 HCAPLUS
 CN Poly[oxy(methyl-1,2-ethanediyl)],
 α -[2-(ethoxycarbonyl)-2-propenyl]- ω -hydroxy- (9CI) (CA INDEX NAME)



IC ICM C07C0069-54
 ICS C07C0067-58
 CC 35-2 (Chemistry of Synthetic High Polymers)
 ST acrylate ester purifn solvent extn; crosslinkable impurity
 removal solvent extn acrylate; ethoxylated ethylhydroxymethyl acrylate
 purifn gelation prevention
 IT Polyoxyalkylenes, preparation
 (acrylate-terminated; purification of acrylate ester derivs. by solvent
 extraction)
 IT 183892-60-6P 184014-31-1P
 (purification of acrylate ester derivs. by solvent extraction)

L50 ANSWER 15 OF 15 HCAPLUS COPYRIGHT 2010 ACS on STN

ACCESSION NUMBER: 1997:618604 HCAPLUS Full-text

DOCUMENT NUMBER: 127:322093

ORIGINAL REFERENCE NO.: 127:63071a,63074a

TITLE: Polyoxyalkylene cement dispersing agent
 for high concrete strength and cement composition
 containing it

INVENTOR(S): Nagano, Hideaki; Maita, Takeshi; Nagare, Koichiro

PATENT ASSIGNEE(S): Nippon Shokubai Kagaku Kogyo Co., Ltd., Japan;
 Nippon Shokubai Co., Ltd.

SOURCE: Jpn. Kokai Tokkyo Koho, 16 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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JP 09241059	A	19970916	JP 1996-46499	19960304
			<--	
JP 3689822	B2	20050831		
PRIORITY APPLN. INFO.:			JP 1996-46499	19960304
			<--	

AB The cement dispersing agent contains a polymer prepared by polymerization of a monomer composition containing the oxyacrylic acid or its ester monomer $\text{CH}_2:\text{CCH}_2\text{O}[\text{CH}_2(\text{CR}_1\text{H})_n\text{O}]_m\text{R}_2\text{CO}_2\text{R}_3$ ($\text{R}_1, \text{R}_2 = \text{H}$, organic residue; $\text{R}_3 = \text{H}$, counter ion, organic residue; $n = 1-3$; $m = 1-100$) or its neutralized product. The cement dispersing agent, added to cement paste, mortar, or concrete in small amount, gives water reducing effect, small slump loss, and strength to the cement composition

IT 197649-79-9P
 (polyoxyalkylene cement dispersing agent for high
 concrete strength)

RN 197649-79-9 HCAPLUS

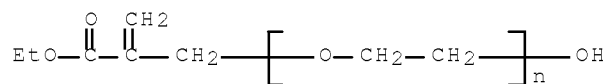
CN 2-Propenoic acid, polymer with
 α -[2-(ethoxycarbonyl)-2-propenyl]- ω -hydroxypoly(oxy-1,2-ethanediy1), graft, sodium salt (9CI) (CA INDEX NAME)

CM 1

CRN 197649-78-8
 CMF (C3 H4 O2 . (C2 H4 O)n C6 H10 O3)x
 CCI PMS

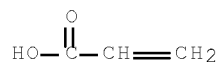
CM 2

CRN 183892-60-6
 CMF (C2 H4 O)n C6 H10 O3
 CCI PMS



CM 3

CRN 79-10-7
 CMF C3 H4 O2



- IC ICM C04B0024-26
- ICS C04B0028-02; C08F0290-06; C08F0299-02; C04B0103-40
- CC 58-1 (Cement, Concrete, and Related Building Materials)
- ST mortar polyoxyalkylene cement dispersing agent; concrete polyoxyalkylene cement dispersing agent
- IT Polyoxyalkylenes, preparation
 (acrylic; polyoxyalkylene cement dispersing agent for high concrete strength)
- IT Cement (construction material)
 Concrete
 Dispersing agents
 Mortar
 (polyoxyalkylene cement dispersing agent for high concrete strength)
- IT 167763-00-0P 197649-77-7P 197649-79-9P
 (polyoxyalkylene cement dispersing agent for high concrete strength)